

# UV and IR generation in silica-based optical fibres and tapers

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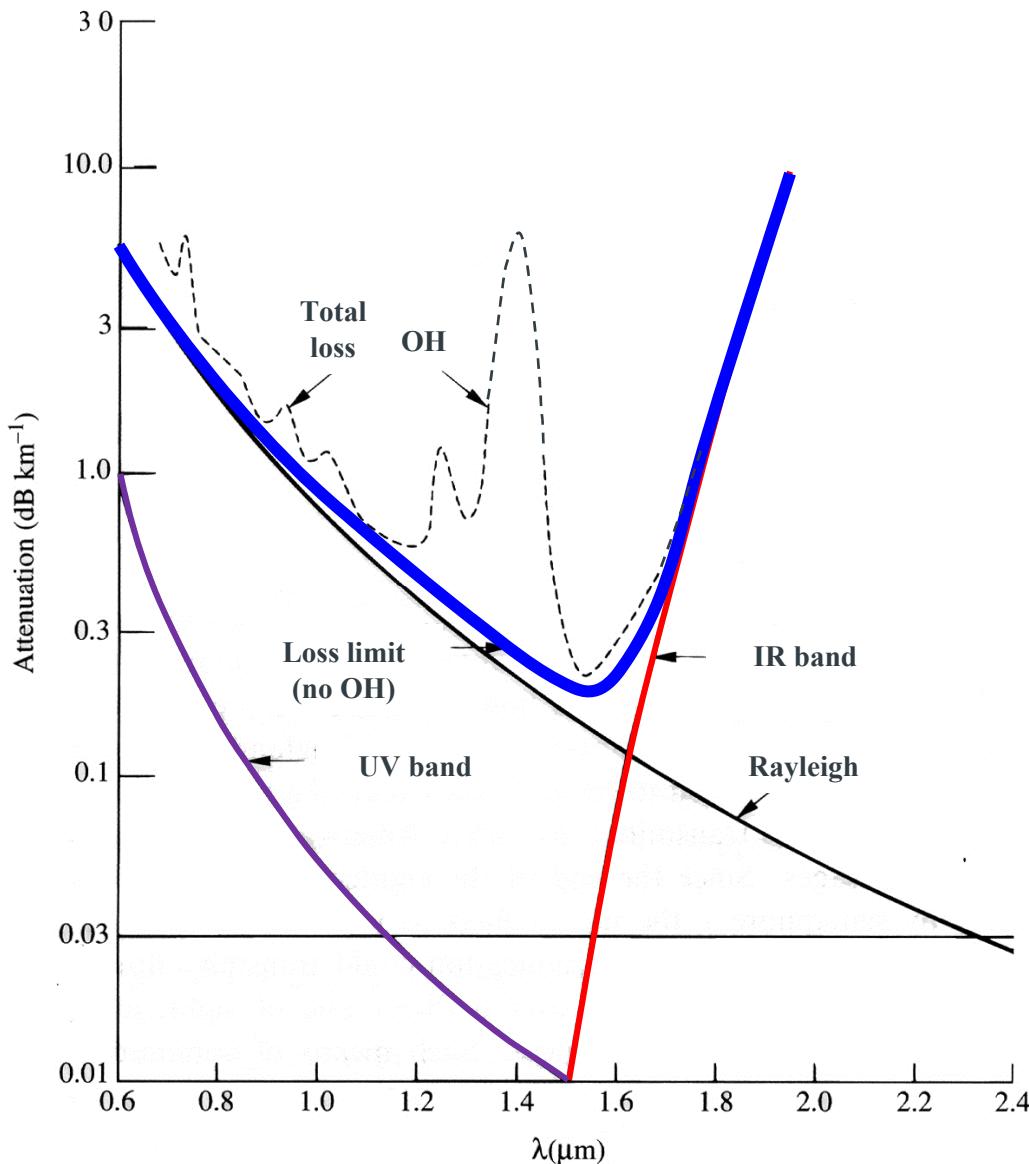
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Singapore, 1 July 2013

# Outline

- Introduction
- $\chi^3$  nonlinear process
- UV generation (THG)
- IR generation (TPG)
- Conclusion

# Introduction: optical fibre loss



Introduction

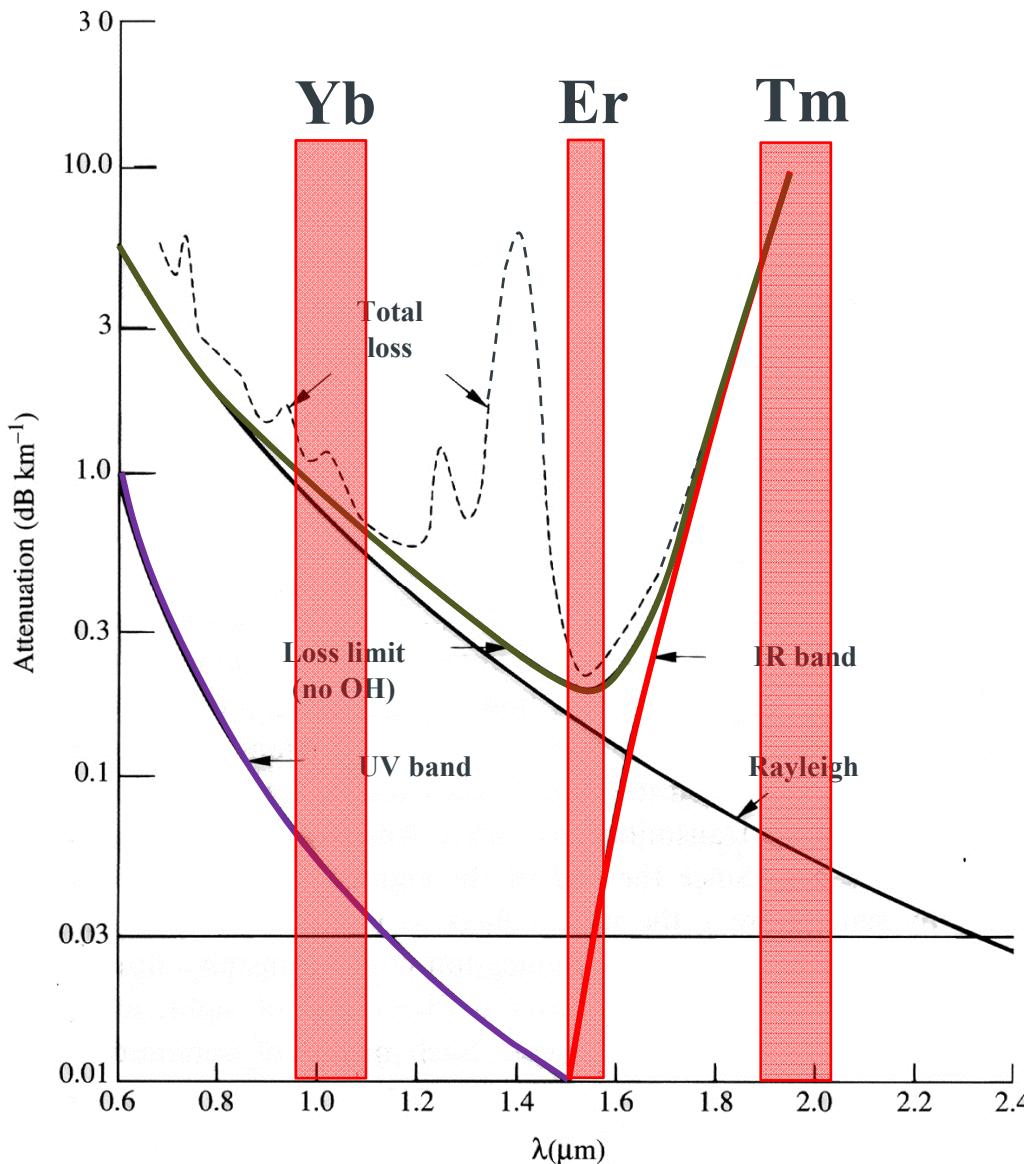
Nonlinear  
processes

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# Optical fibre lasers



Introduction  
Fibre lasers

Nonlinear  
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# Introduction: optical fibre laser

Advantages include:

- Efficient cooling: high surface to volume ratio
- Thus, no thermal lensing and high-quality optical beam:  $M^2 \sim 1$
- High brightness
- High output power: active regions in long, thus very high optical gain
- Compact, reliable
- Light is already coupled into a flexible fibre

Introduction  
Fibre lasers

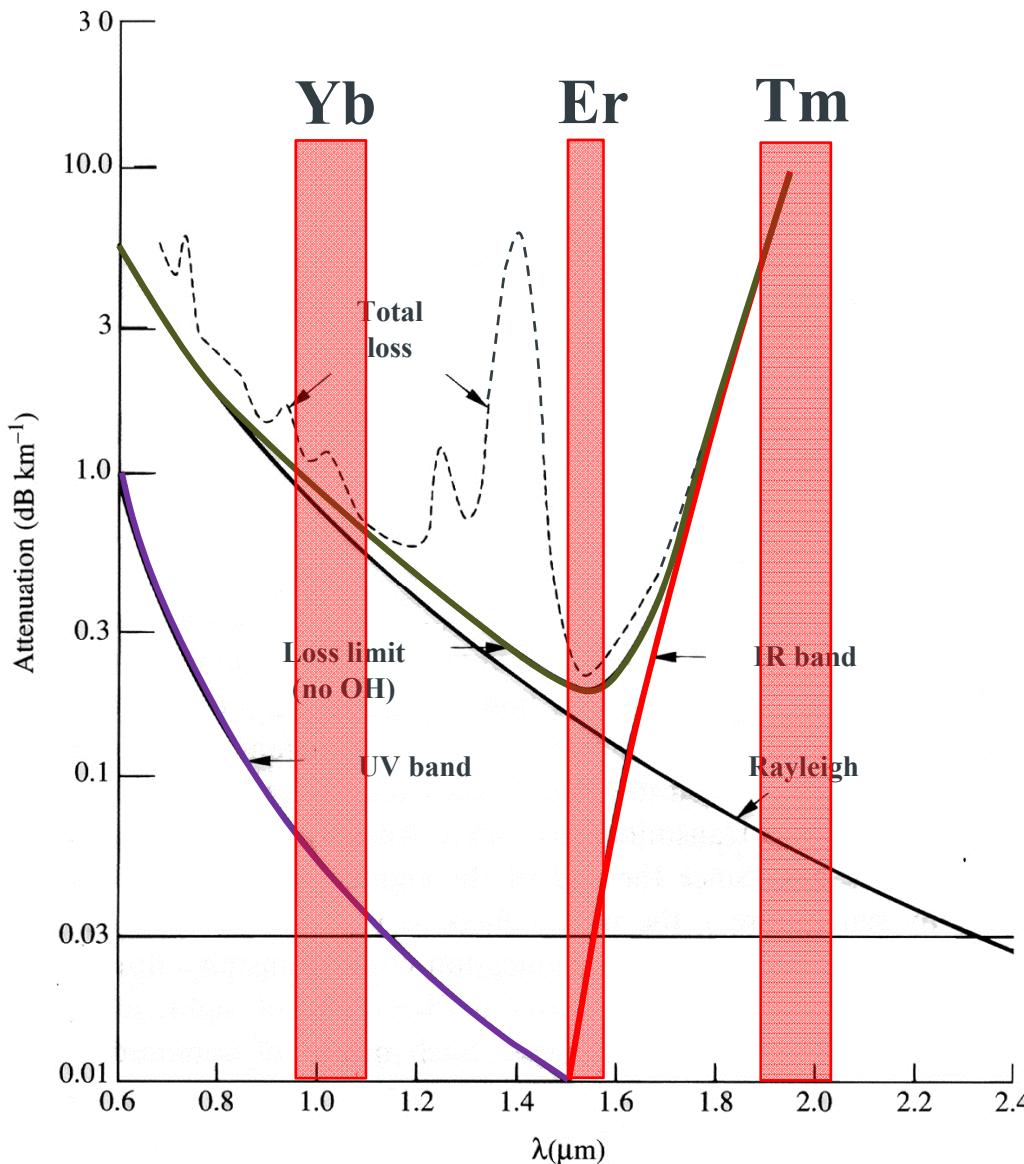
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# Optical fibre lasers



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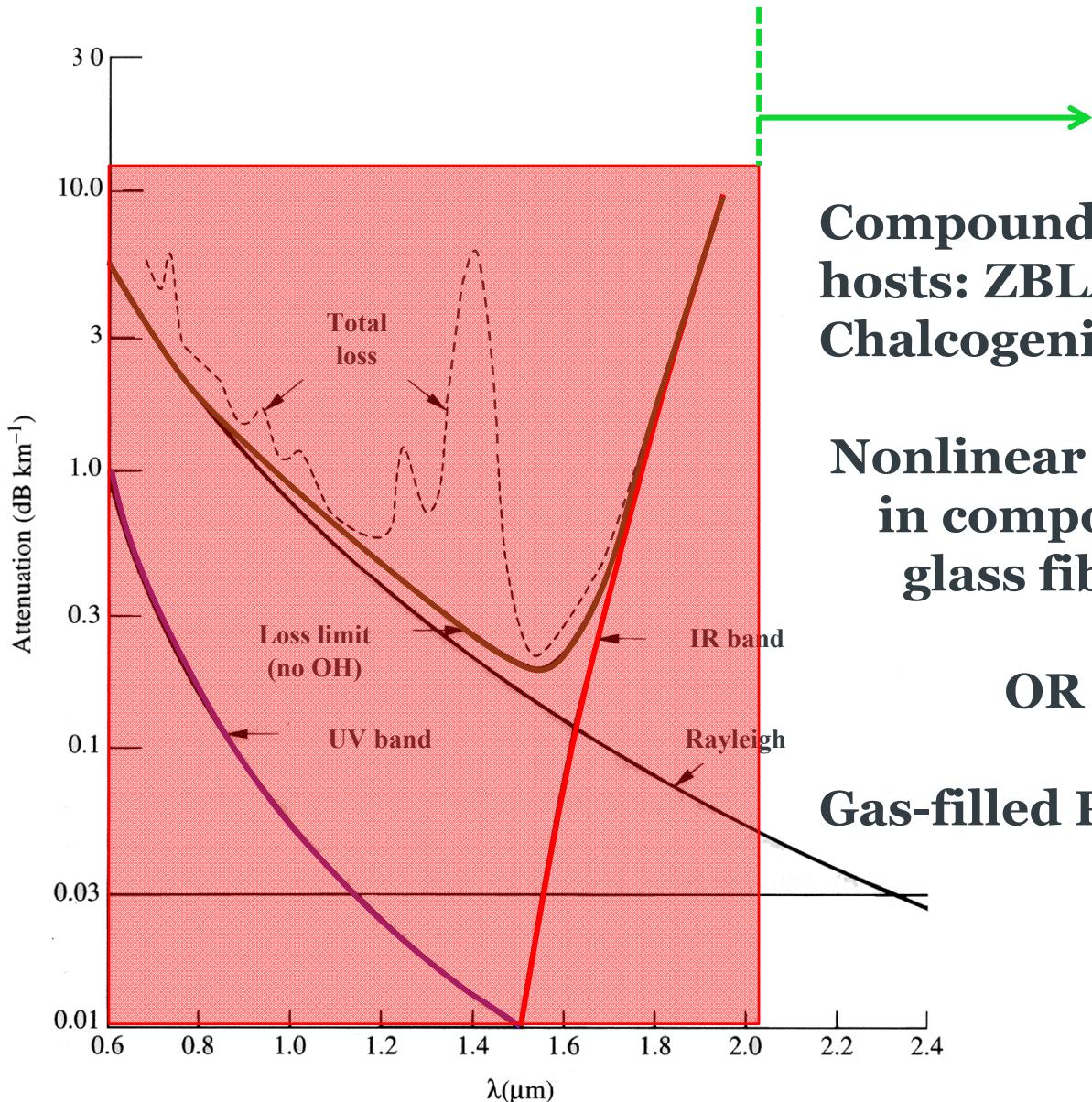
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# Optical fibre lasers



**Compound glass hosts: ZBLAN, Chalcogenides**

**Nonlinear Optics in compound glass fibres**

**OR**

**Gas-filled PBGF**

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Fibre lasers

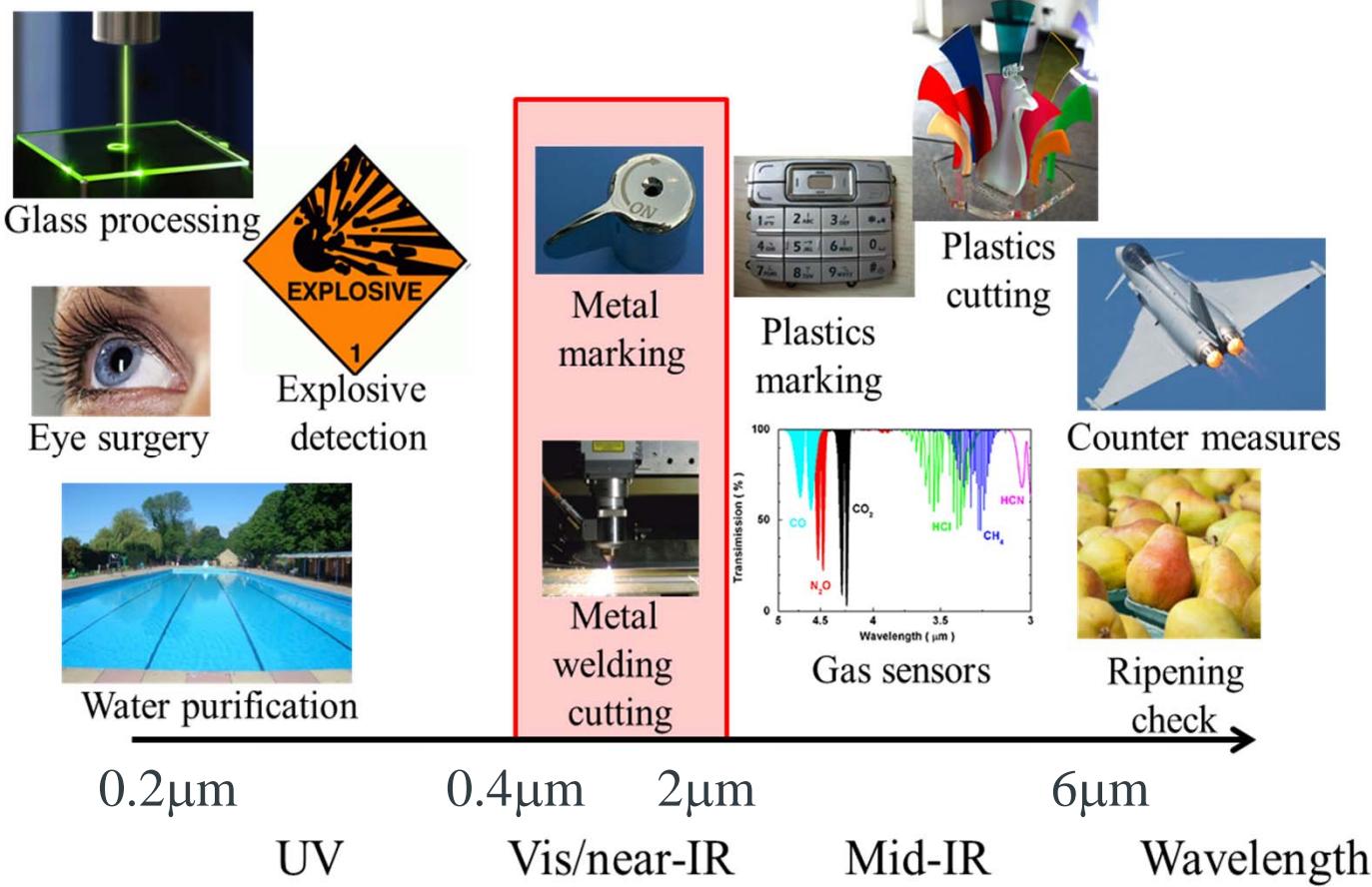
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# Laser applications



## Introduction Applications

Nonlinear processes

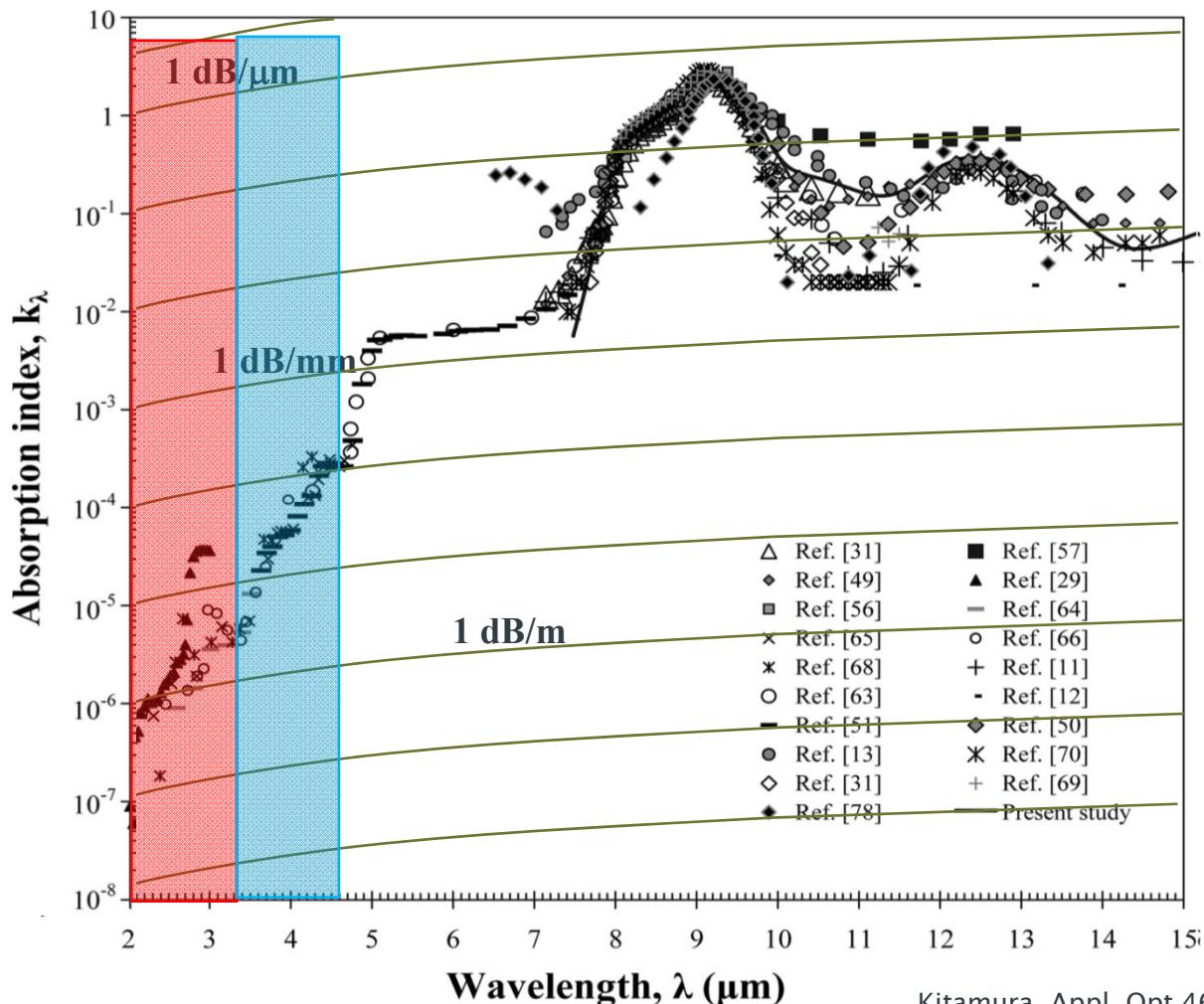
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# Silica loss: long $\lambda$

3 dB/m 1 dB/cm  
Active Nonlinear  
fibres processes



Kitamura, Appl. Opt 46(33), 8118, 2007.

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Silica loss

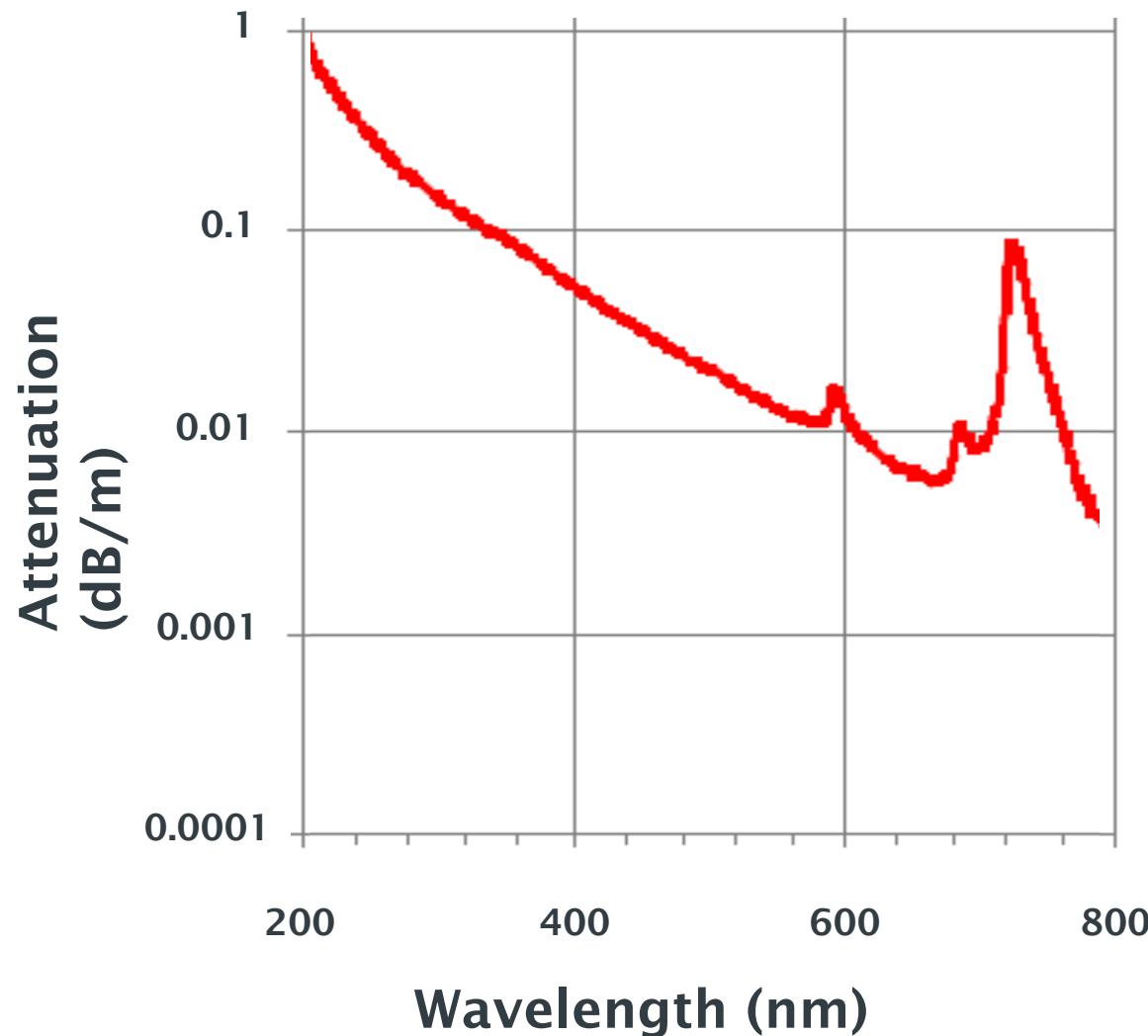
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# Silica loss: short $\lambda$



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# Nonlinear processes

## Requirements:

- **Efficient (few cm of fibre at most)**
- **Pump must be in low loss wavelength region (500nm-2μm)**
- **Compatible with fibre material (glass) (no  $\chi^{(2)}$ ).**
- **Compatible with fibre geometry**

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# Nonlinear processes: UV

## Third Harmonic Generation



- It uses  $\chi^{(3)}$
- Pump is in the low loss wavelength region (500nm-2μm)
- Compatible with glass and fibre geometry.

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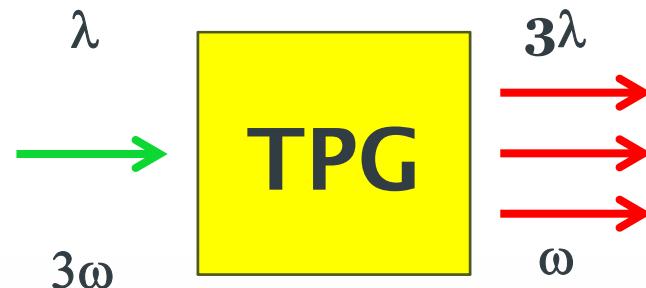
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# Nonlinear processes: IR

## Three Photon Generation



- It uses  $\chi^{(3)}$
- Pump is in the low loss wavelength region (500nm-2μm)
- Compatible with glass and fibre geometry.

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# THG - TPG

## Third Harmonic / Three photon Generation

- **Phase matching**

$$\Delta\beta = \beta(3\omega) - 3\beta(\omega) \approx 0,$$

- **High overlap between pump and third harmonic mode**

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# Third Harmonic Generation Phase matching

Third harmonic generation is efficient if

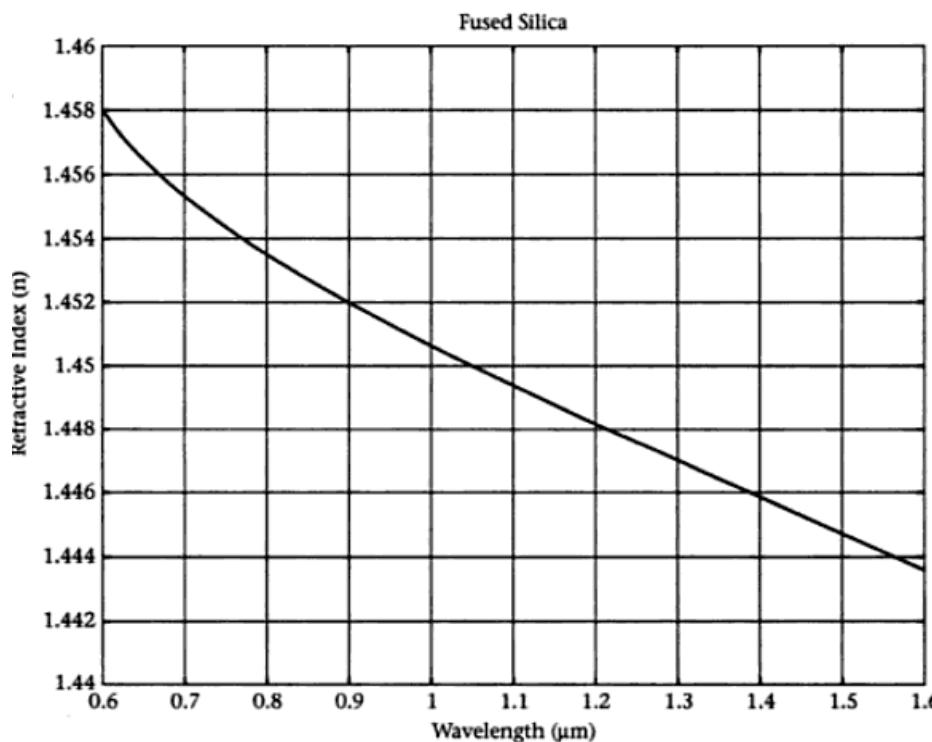
$$\beta(\omega) = \beta(3\omega)$$

$$\beta = n_{\text{eff}} (2\pi/\lambda)$$

$$n_{\text{eff}} = \frac{\iint\limits_{0 0}^{2\pi\infty} n(r, \theta) I(r, \theta) dr d\theta}{\iint\limits_{0 0}^{2\pi\infty} I(r, \theta) dr d\theta}$$

refractive index      mode intensity distribution

radial coordinate      azimuthal coordinate



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# Phase matching

$n_{\text{eff}}$  depends

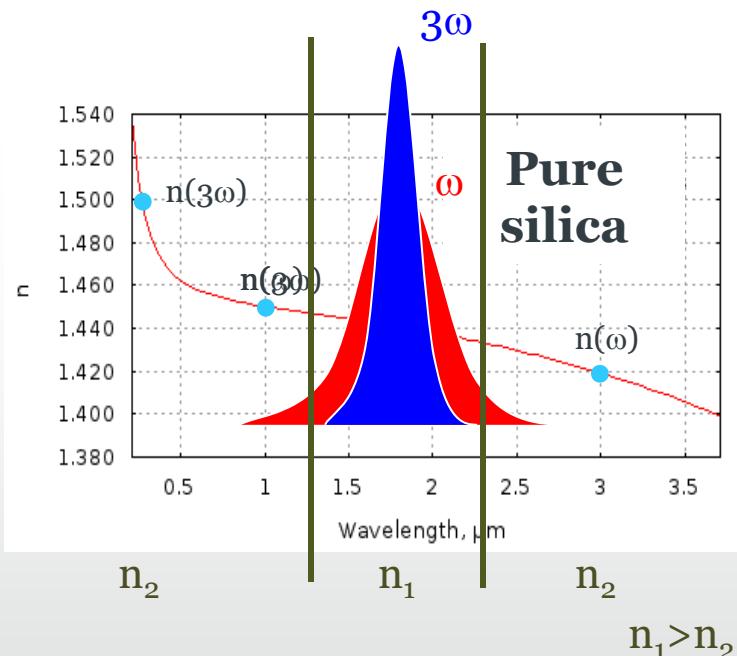
- Material dispersion

$$n_{\text{eff}}(3\omega) \gg n_{\text{eff}}(\omega)$$

- Mode confinement  
for fundamental mode

$$n_{\text{eff}}(3\omega) \gg n_{\text{eff}}(\omega)$$

$$n_{\text{eff}} = \frac{\iint\limits_0^{2\pi\infty} n(r, \vartheta) I(r, \vartheta) dr d\vartheta}{\iint\limits_0^{2\pi\infty} I(r, \vartheta) dr d\vartheta}$$



**BUT  $n_{\text{eff}}$  decreases for mode order**

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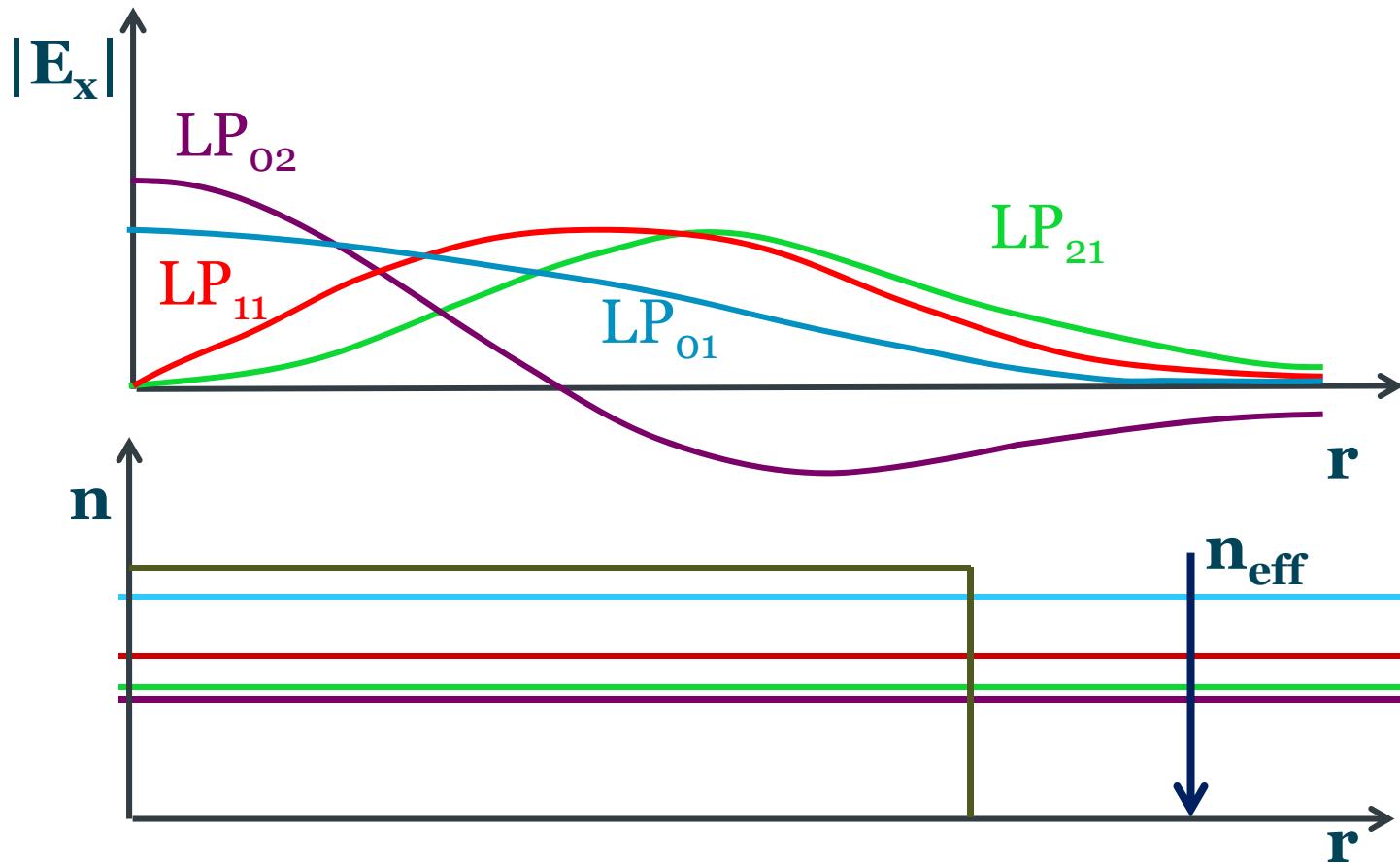
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# THG: high order mode $n_{\text{eff}}$



**High order modes extend further in the low  $n$  medium  
they have a lower  $n_{\text{eff}}$ .**

**intermodal phase matching**

Grubsky, Opt. Lett., 2005

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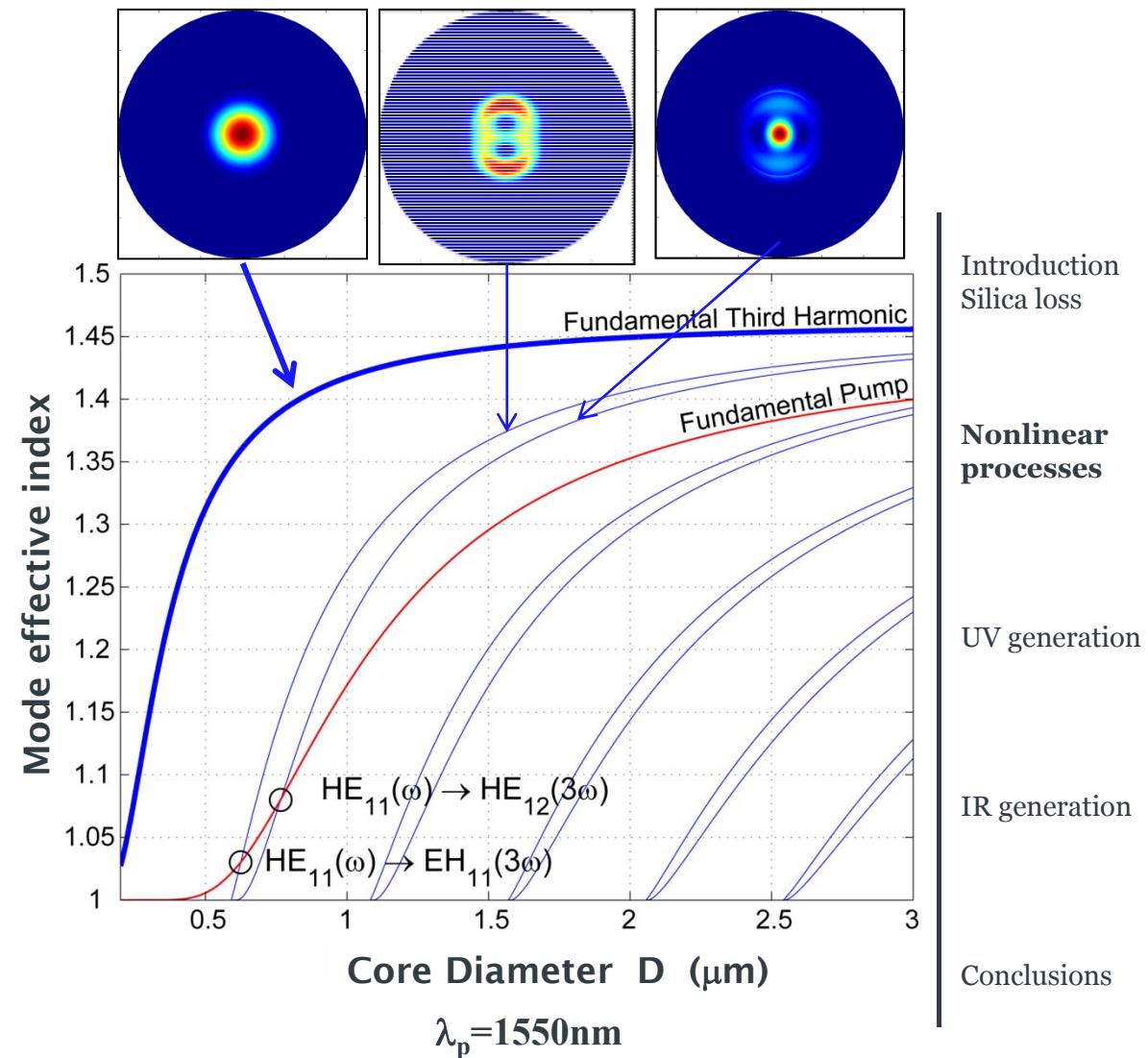
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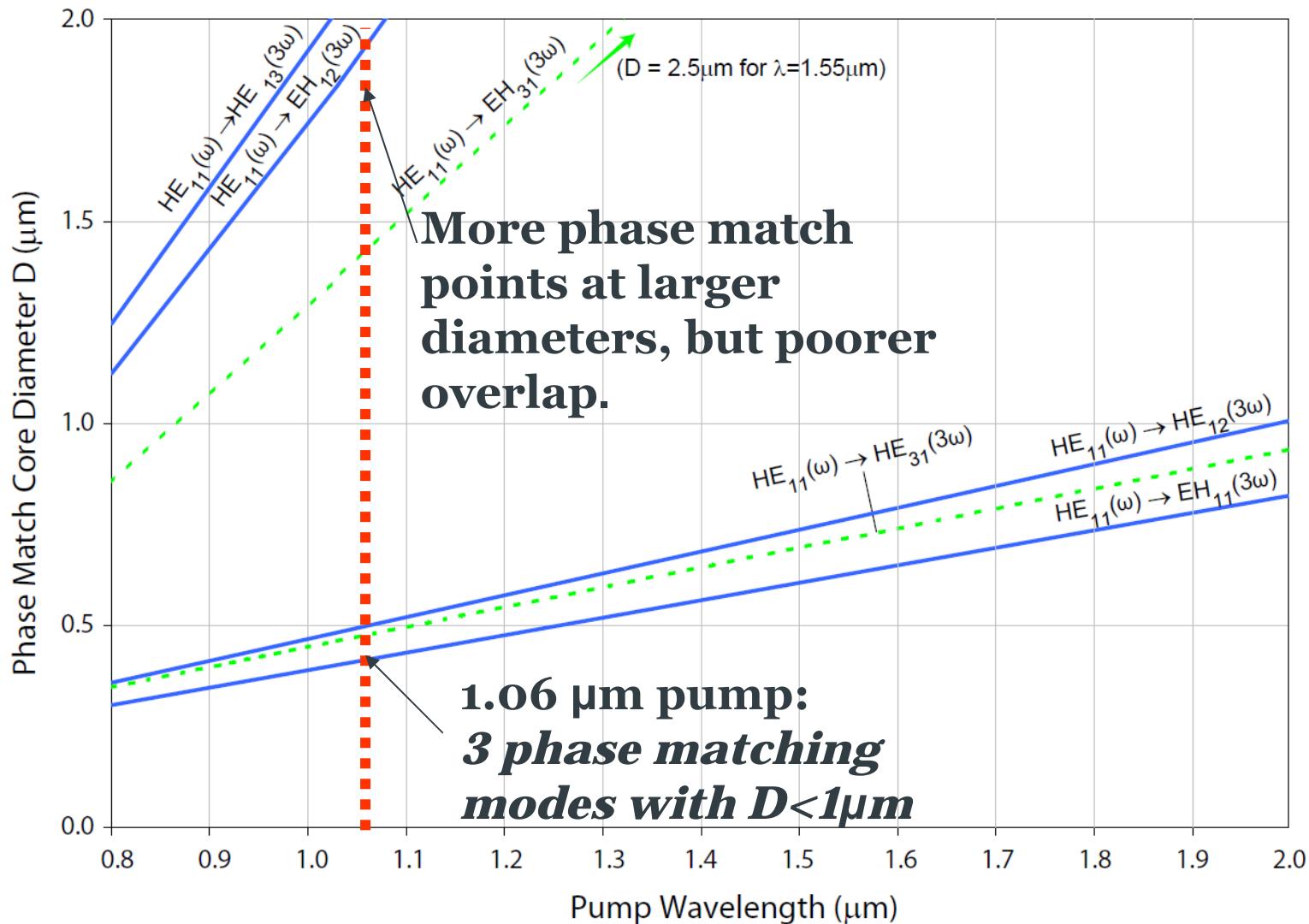
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# Phase matching

- Fundamental  $HE_{11}(\omega)$  pump mode can be phase matched only to higher order third harmonic modes.
- For pump  $\lambda_p$ , critical diameters exist at  $\sim \lambda_p/2$  for  $NA \sim 1$ .



# Phase matching



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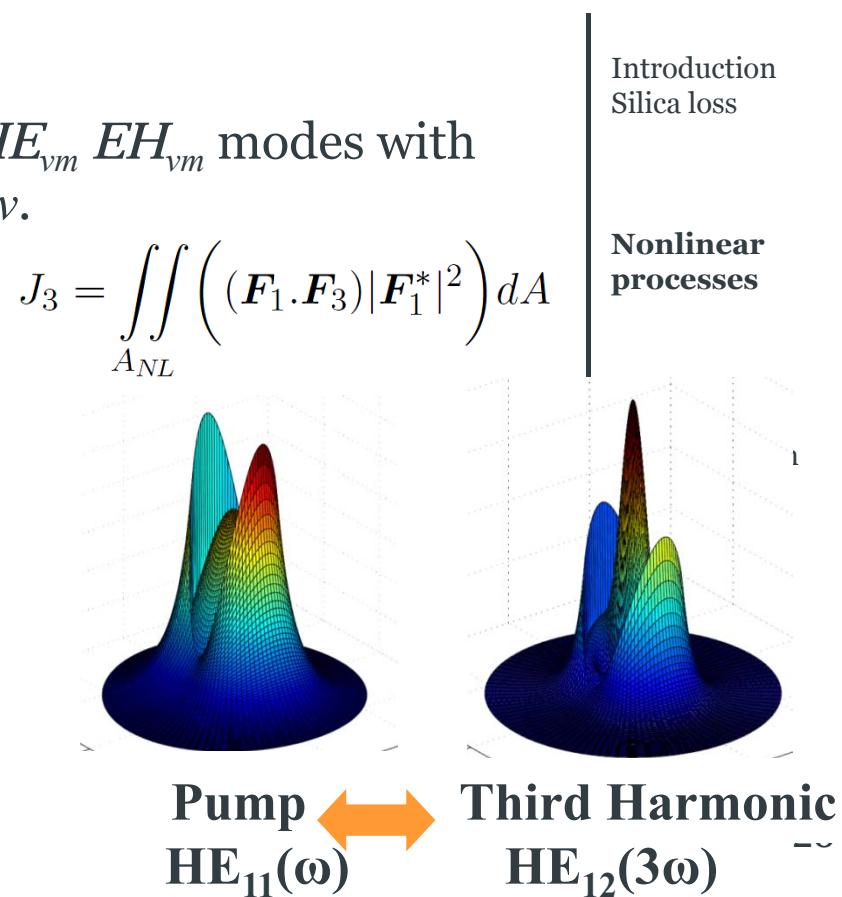
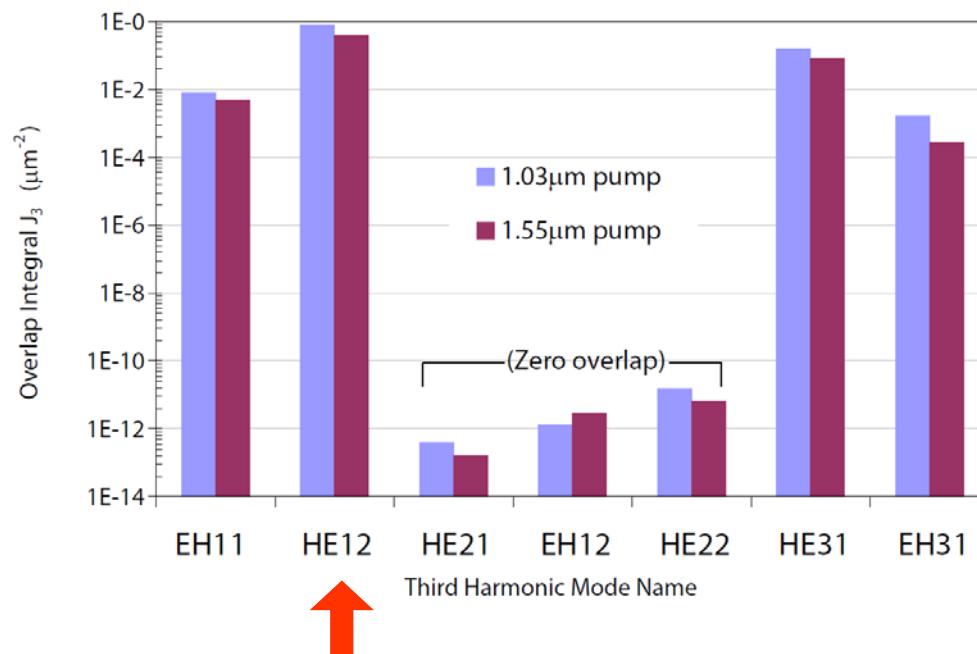
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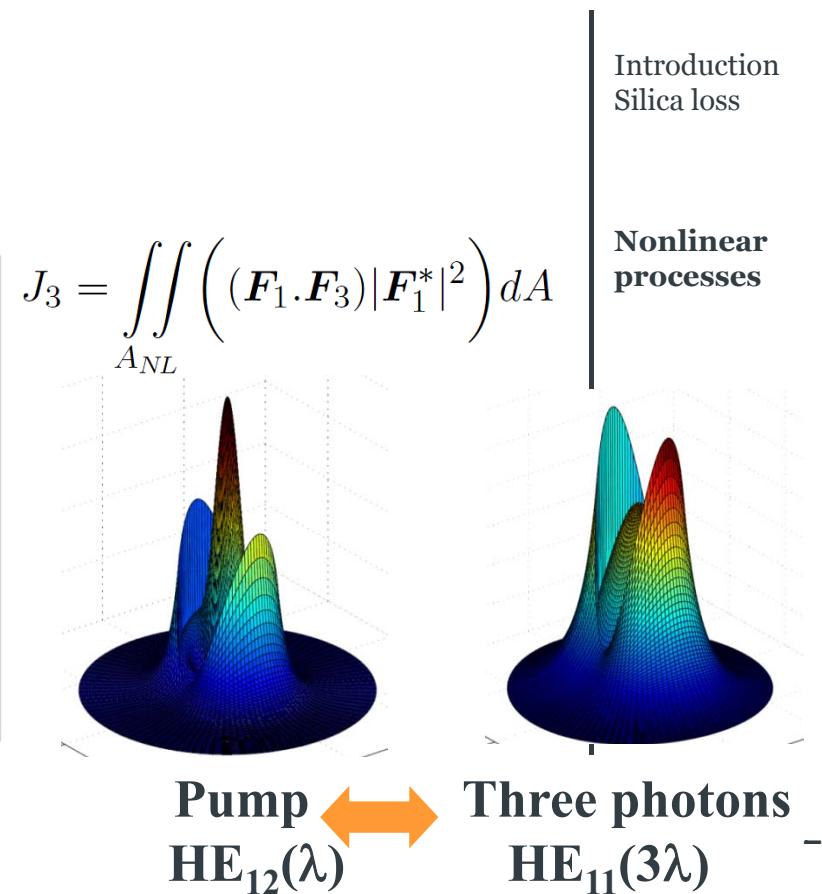
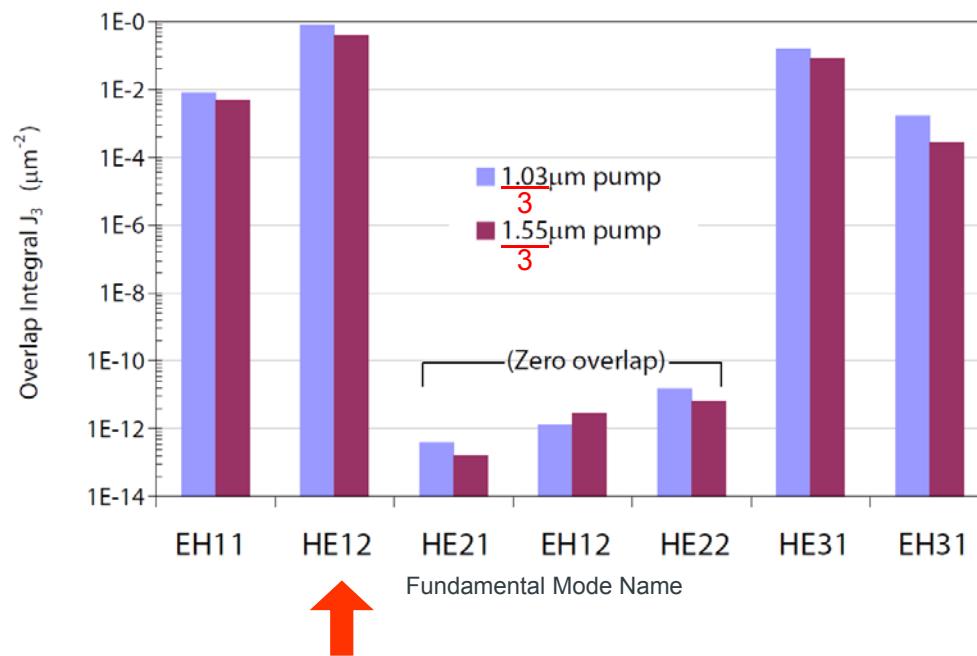
# THG: Overlap

- Overlap between pump and TH mode governs efficiency.
- HE<sub>12</sub>(3ω) overlap is greatest: 0.76 μm<sup>-2</sup> for a 1.0 μm pump
- It increases for decreasing wavelengths (it is 0.38 μm<sup>-2</sup> for 1.55 μm pump).
- Overlap is zero *TE*, *TM* and hybrid *HE<sub>vm</sub>* *EH<sub>vm</sub>* modes with even azimuthal mode order number *v*.



# TPG: Overlap

- Overlap between pump and TP mode governs efficiency.
- $HE_{12}(\lambda)$  overlap is greatest.
- Pump is in high order mode!



# THG: experiment

Taper

$D = 0.78 \mu\text{m}$ ,

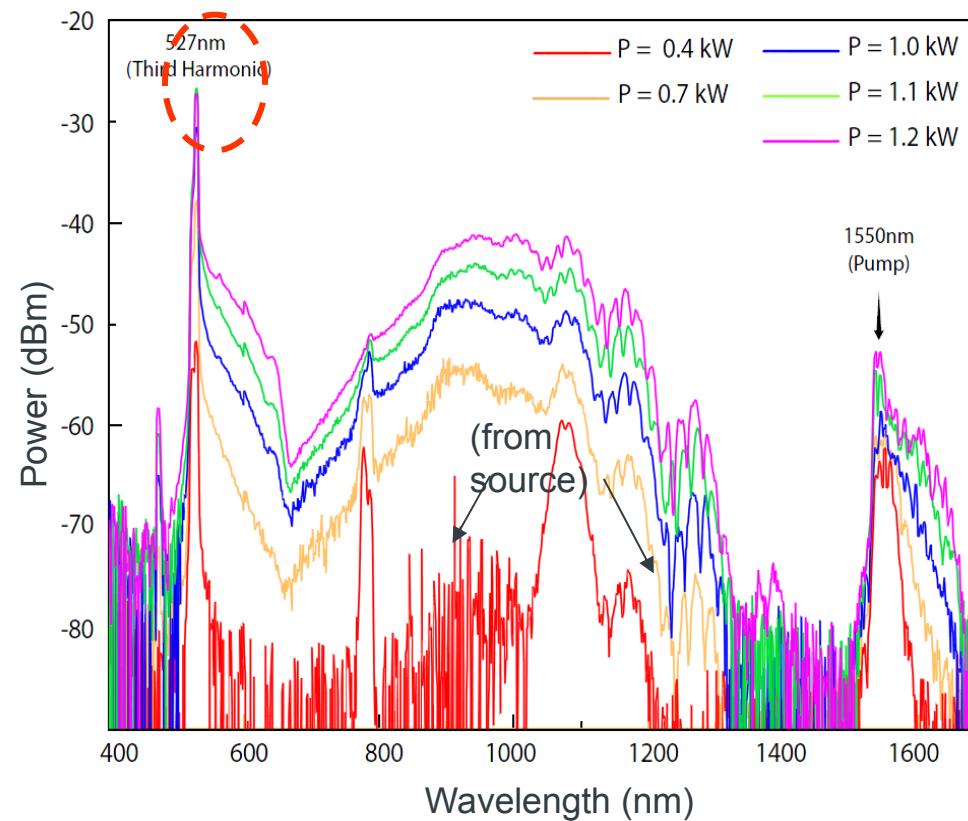
$L \sim 200\mu\text{m}$

- Diameter is closer to critical value.
- Peak at 527nm
- asymmetric TH spectrum.

$\eta_{\text{meas}} \sim 10^{-3}$

$\eta_{\text{th}} = 2 \cdot 10^{-2}$

Spectrum recorded after  
shortpass filter:



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Silica loss

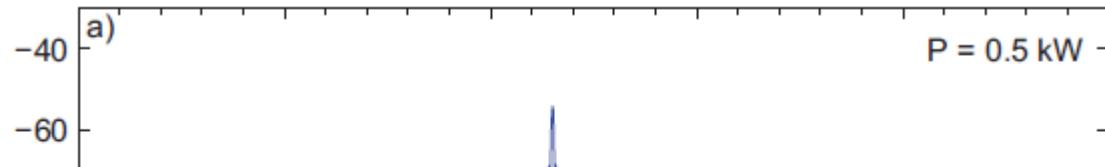
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# THG: broadband generation



## Broadband third harmonic generation in tapered silica fibres

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**Abstract:** Optical microfibres have recently attracted much attention for nonlinear applications, due to their tight modal confinement. Here, we report broadband third harmonic generation based on the intermodal phase matching technique in silica microfibres of several centimetres. The third harmonic signal is predominantly generated from the taper transition regions (rather than the waist), wherein the range of diameters permits phase matching over a wide bandwidth. Microfibres up to 4.5 cm long were fabricated with waist diameters below  $2.5 \mu\text{m}$  to allow a  $\lambda = 1.55 \mu\text{m}$  pump to phase match with several higher order third harmonic modes; conversion rates up to  $3 \times 10^{-4}$  were recorded when pumped with 4 ns pulses at a peak power of 1.25 kW. Analysis of the third harmonic frequencies generated from the nonlinearly broadened pump components indicate a 5 dB conversion bandwidth of at least 36 nm, with harmonic power detected over a 150 nm range.

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OCIS codes: (190.0190) Nonlinear optics; (190.2620) Harmonic generation and mixing; (190.4160) Multiharmonic generation; (190.4370) Nonlinear optics, fibers.

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Silica loss

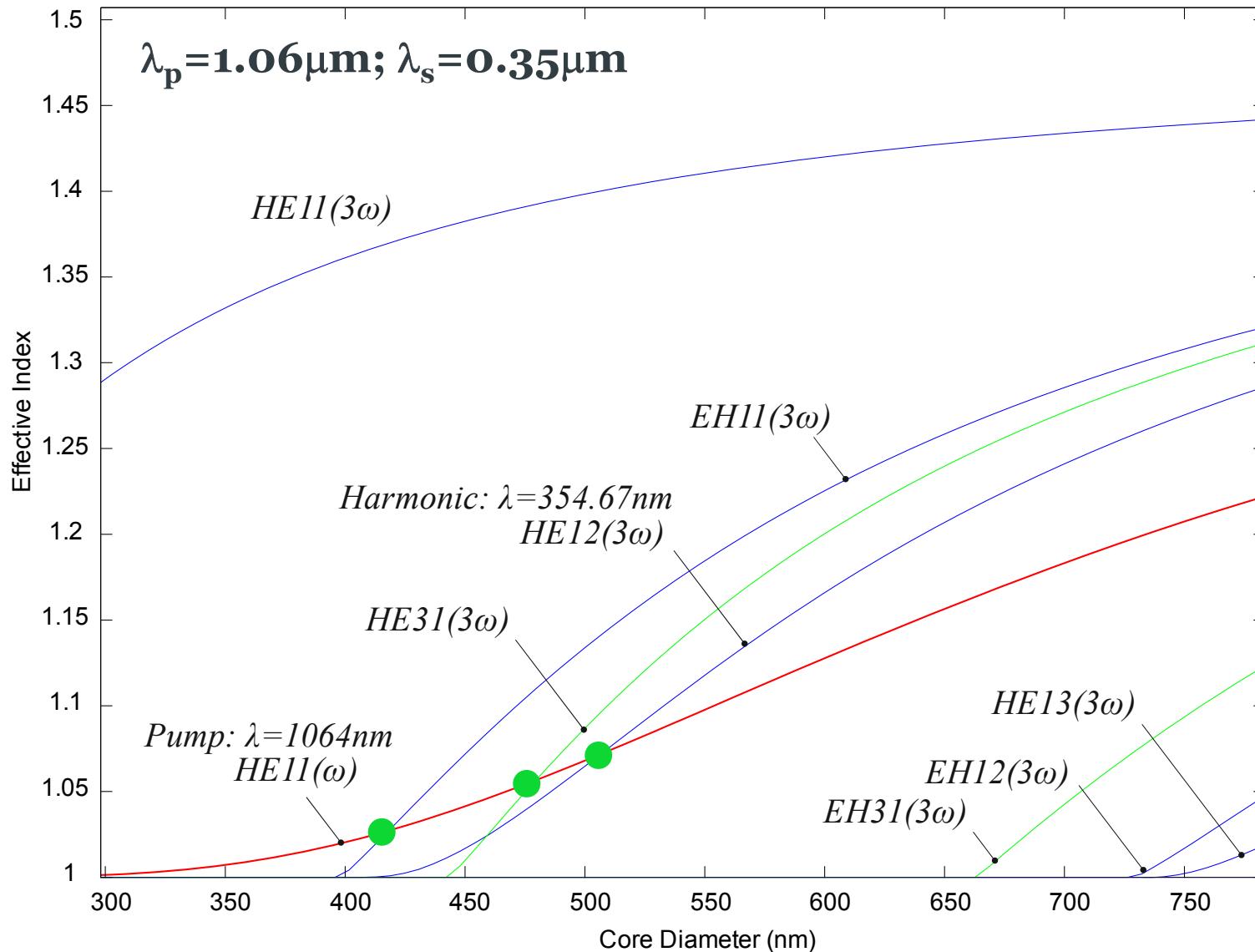
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UV generation

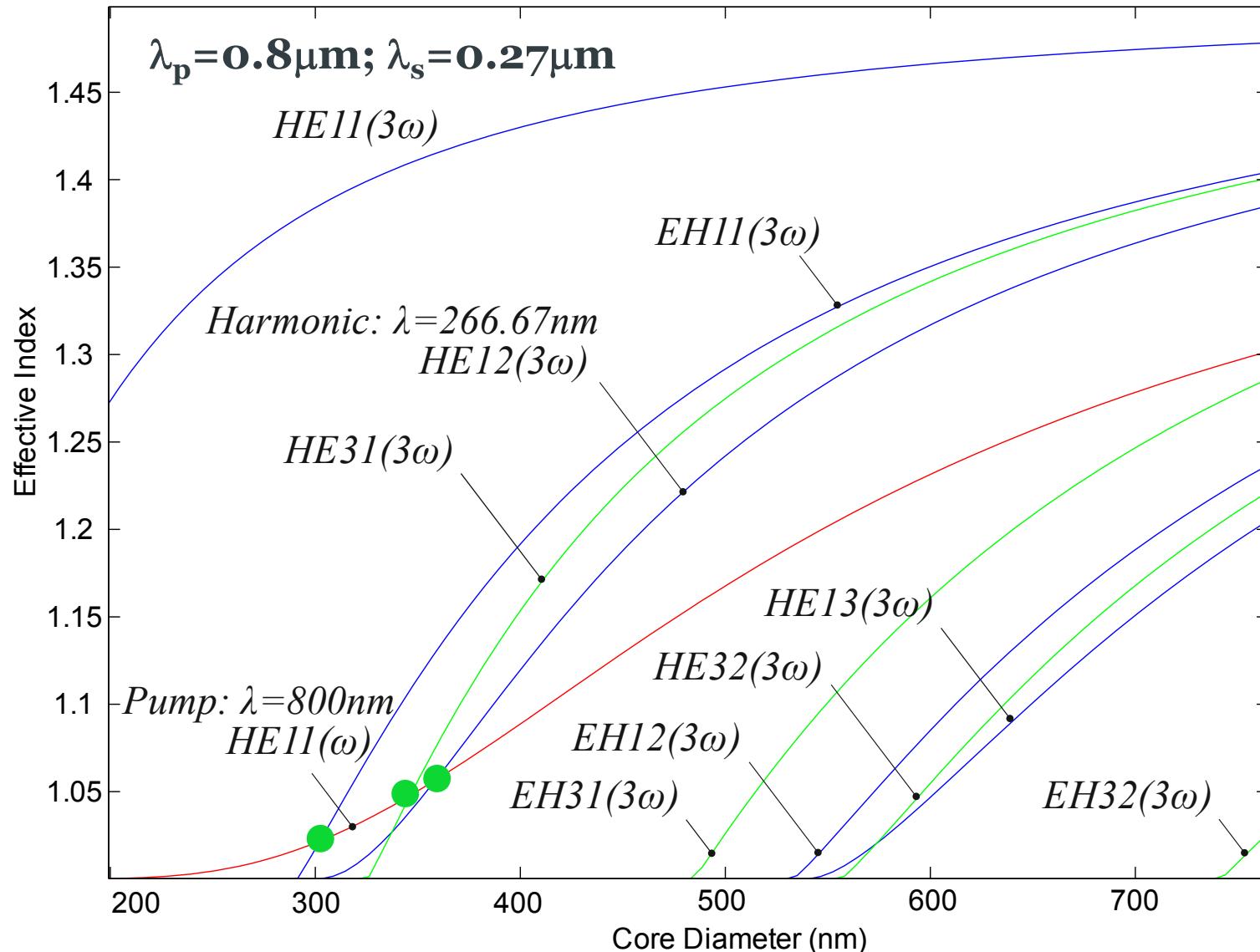
IR generation

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# UV: Phase matching at $\lambda=0.35\mu\text{m}$



# UV: Phase matching at $\lambda=0.27\mu\text{m}$



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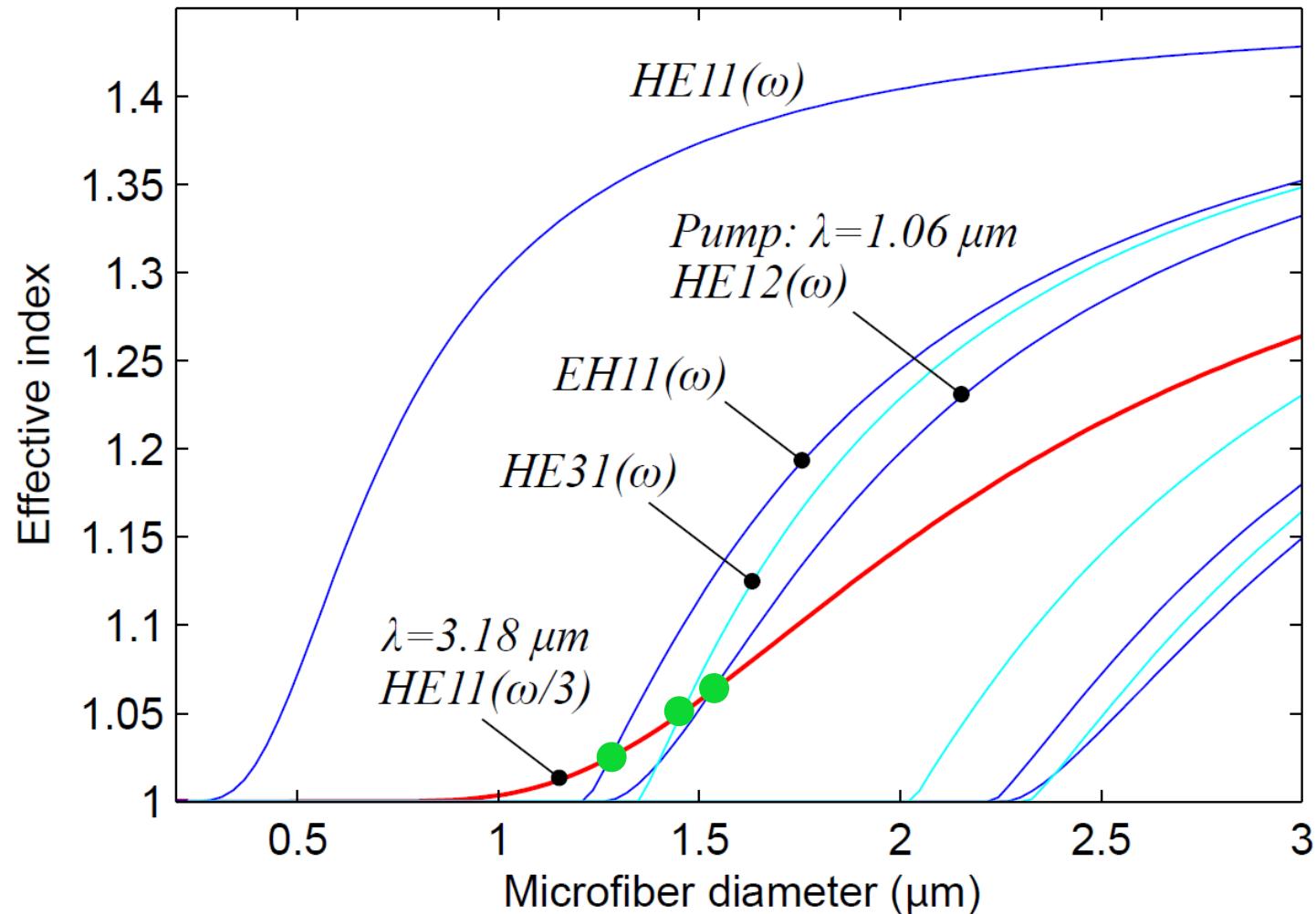
**UV generation**

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# IR: Phase matching at $\lambda=3.18\mu\text{m}$

$\lambda_p=1.06\mu\text{m}$ ;  $\lambda_s=3.18\mu\text{m}$



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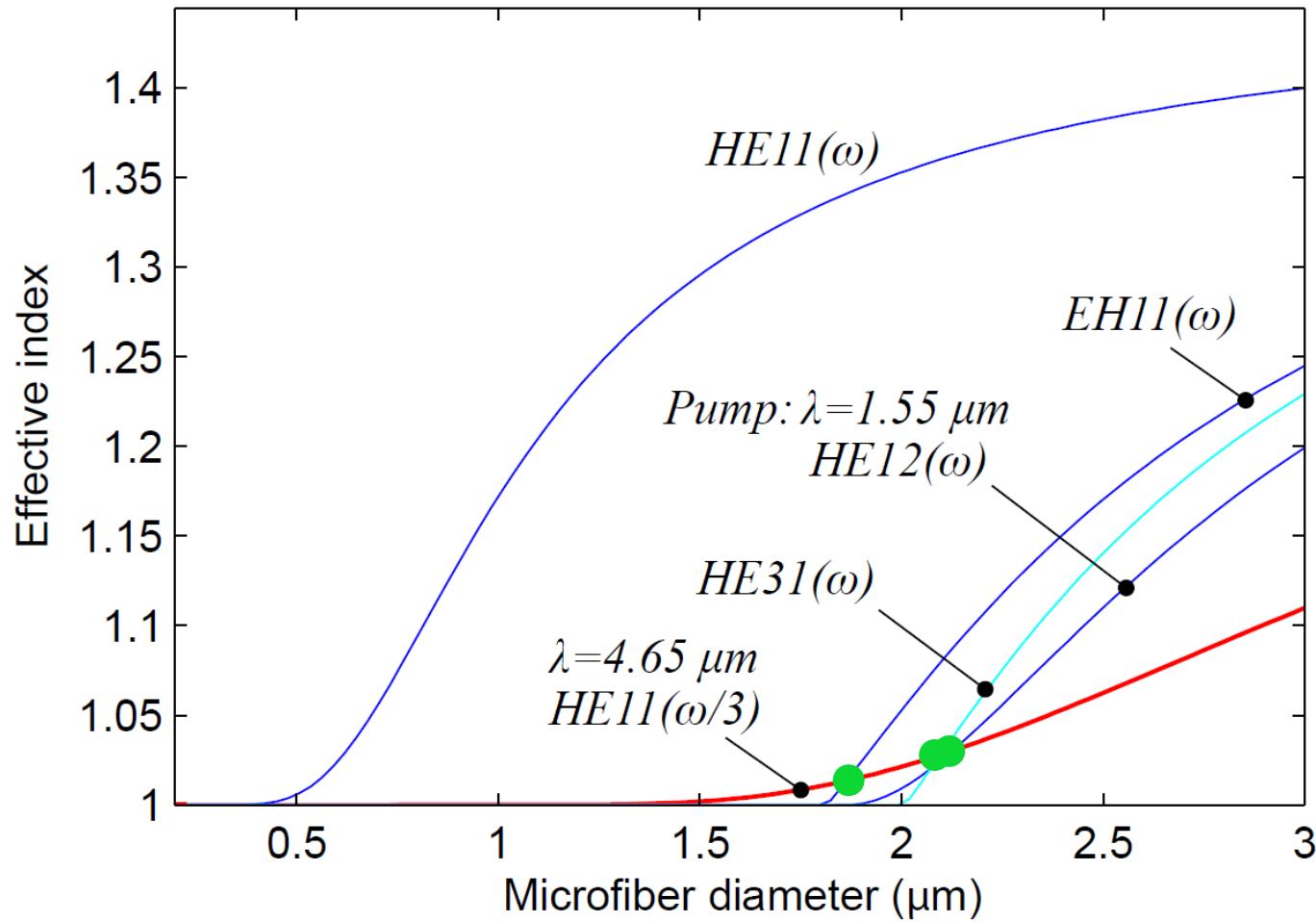
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# IR: Phase matching at $\lambda=4.65\mu\text{m}$

$\lambda_p=1.55\mu\text{m}$ ;  $\lambda_s=4.65\mu\text{m}$



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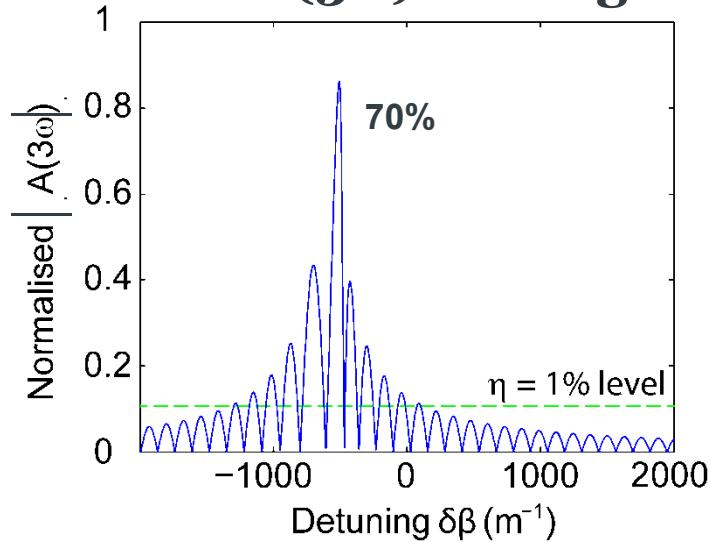
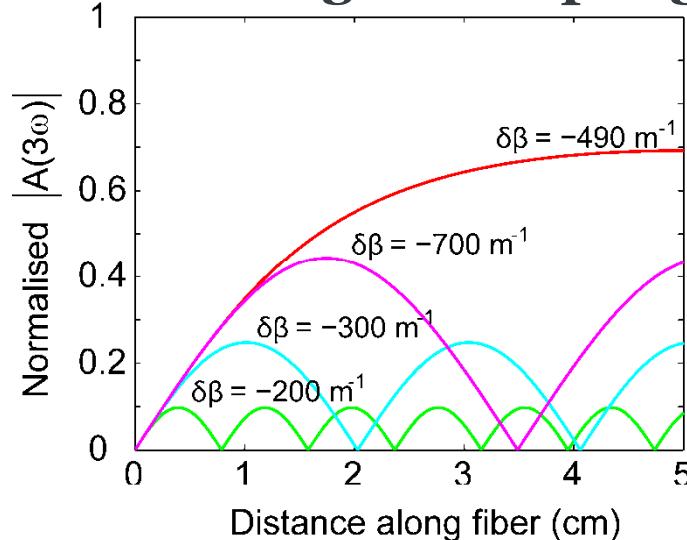
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# THG: conversion efficiency

- THG differential equations [1] :

	SPM	XPM	THG term with detuning
<b>Pump:</b>	$\frac{dA_1}{dz} = in^{(2)}k_1 \left\{ (J_1 A_1 ^2 + 2J_2 A_3 ^2)A_1 + J_3A_1^*A_3e^{i\delta\beta z} \right\}$		
<b>Third Harmonic:</b>		$\frac{dA_3}{dz} = in^{(2)}k_1 \left\{ (6J_2 A_1 ^2 + 3J_5 A_3 ^2)A_3 + J_3^*A_1^3e^{-i\delta\beta z} \right\}$	

- Solving for coupling to the HE12( $3\omega$ ) mode gives:

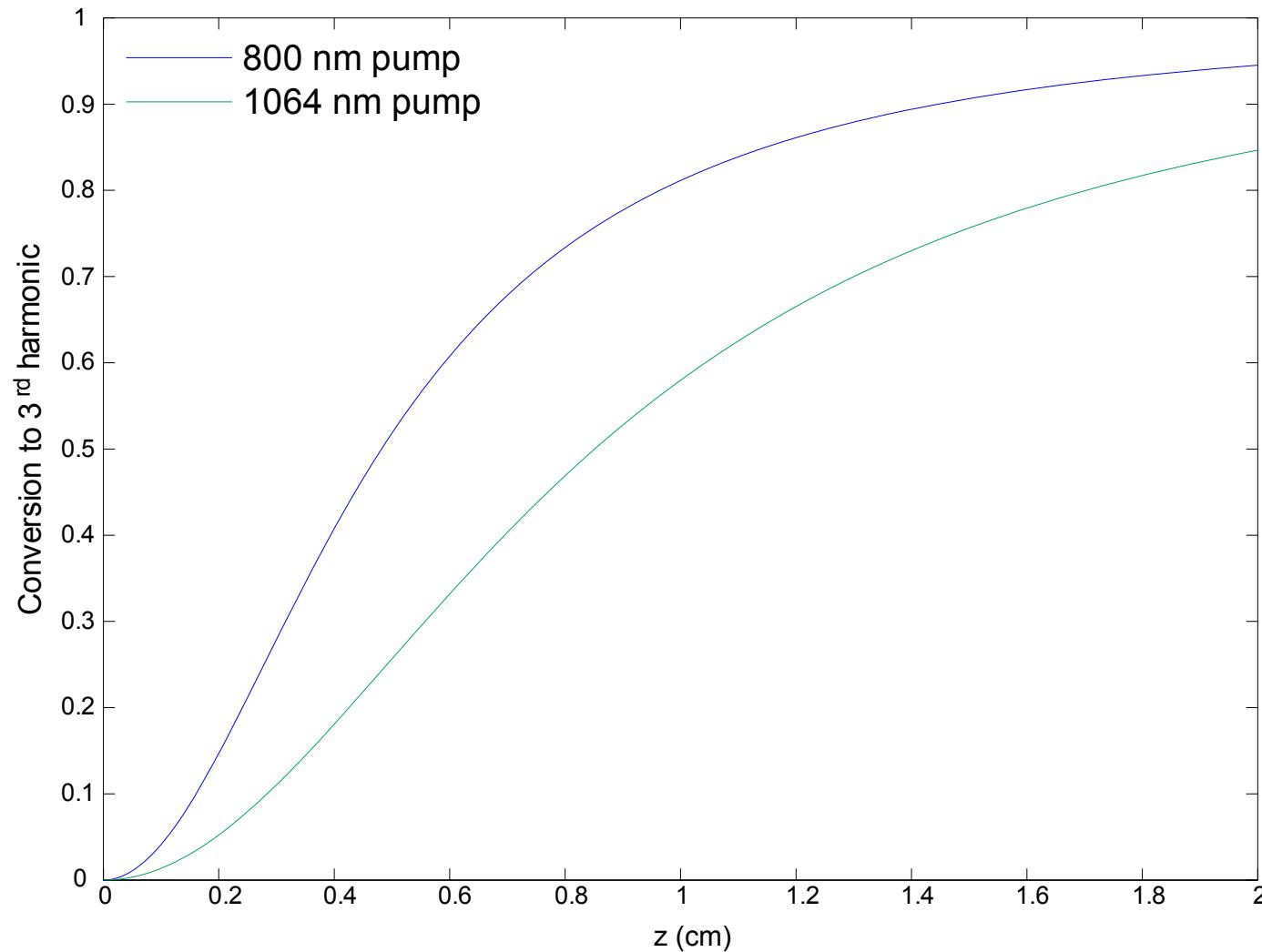


Parameters:

- Length 5cm
- Diameter  $0.77\mu\text{m}$
- $P_{\text{in}} = 1\text{kW}$

[1] V. Grubsky and A. Savchenko, Opt. Expr. 13, 6798 (2006).

# UV conversion efficiency



Introduction  
Silica loss

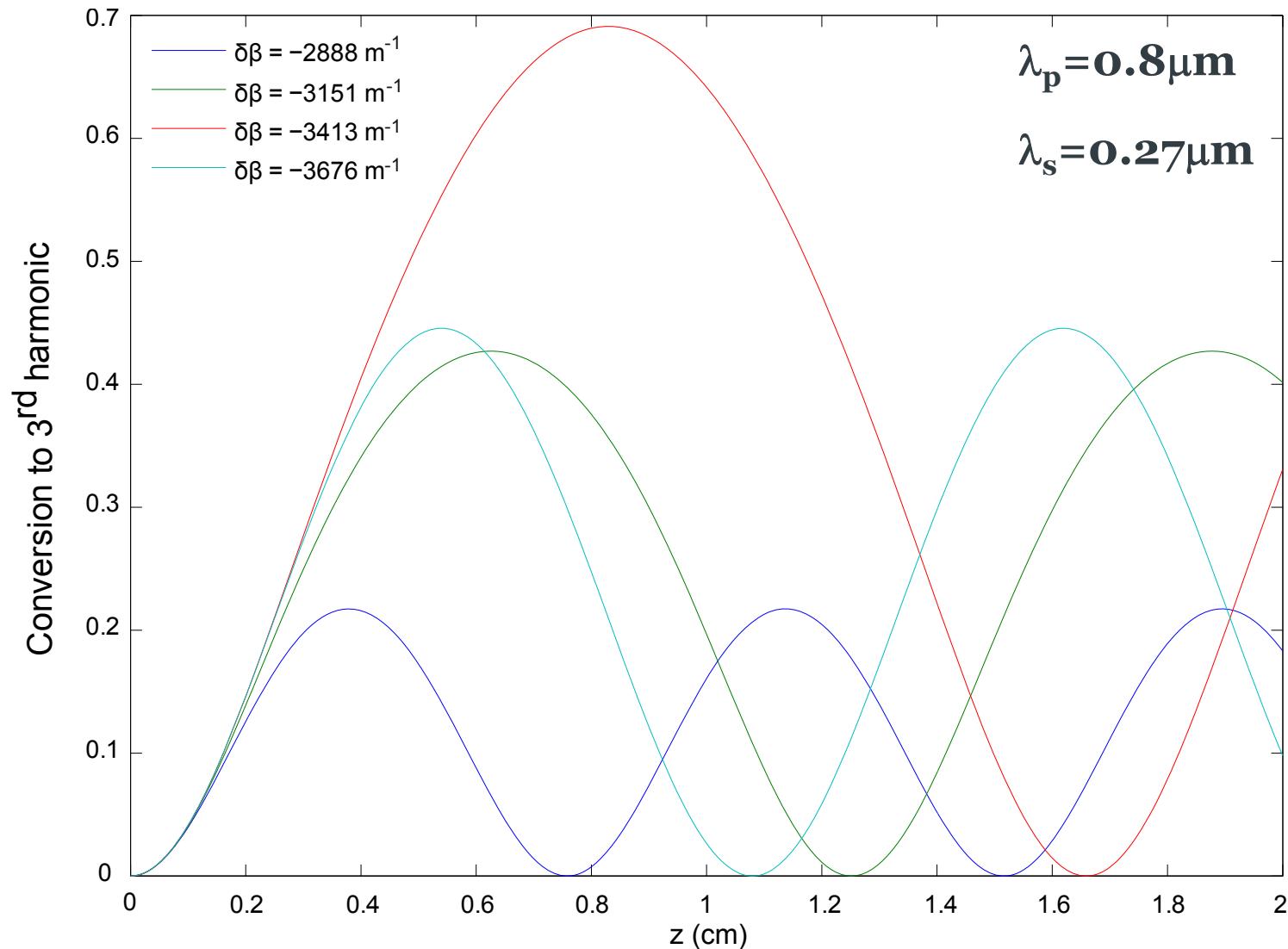
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# THG: detuning



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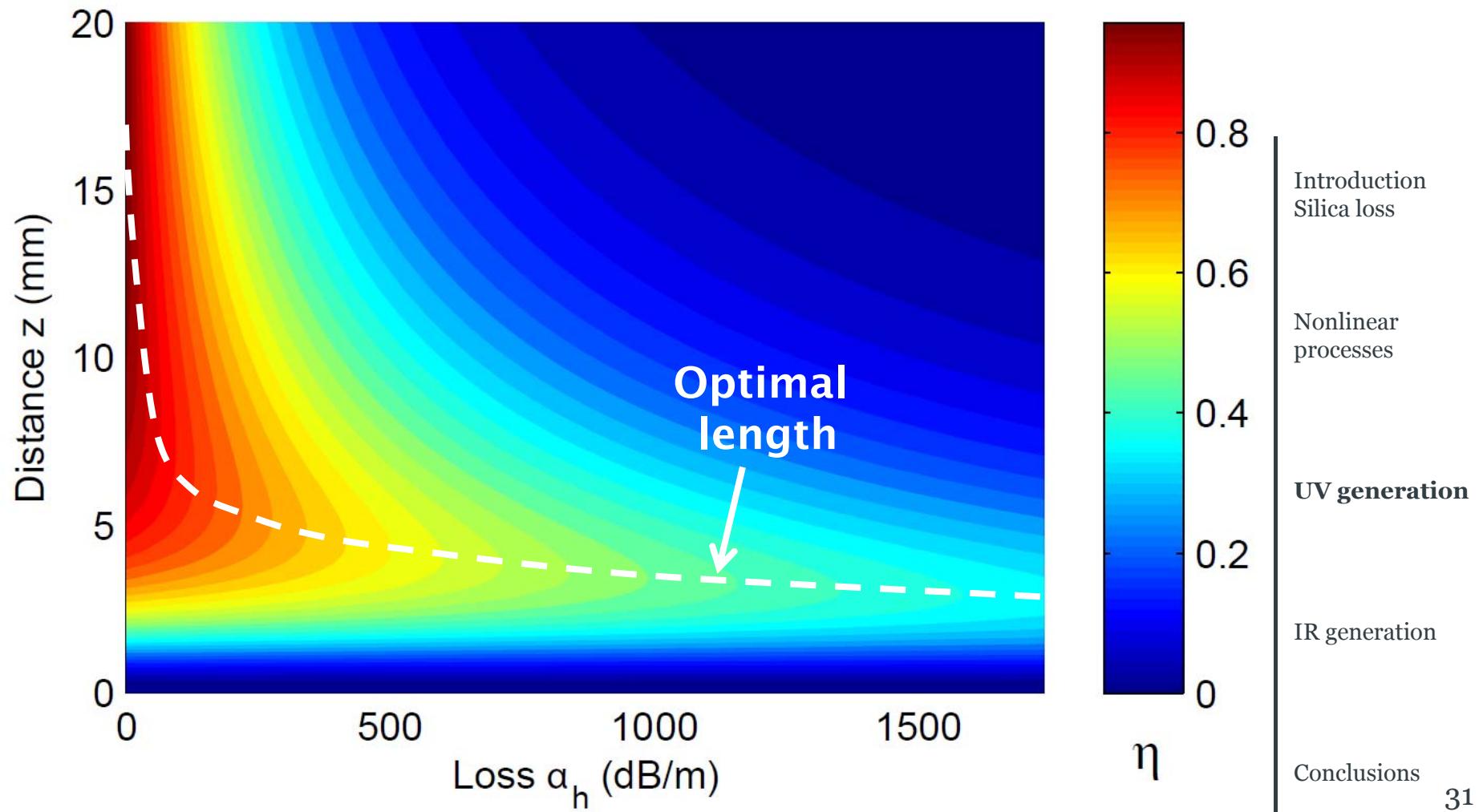
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# THG: Effect of loss

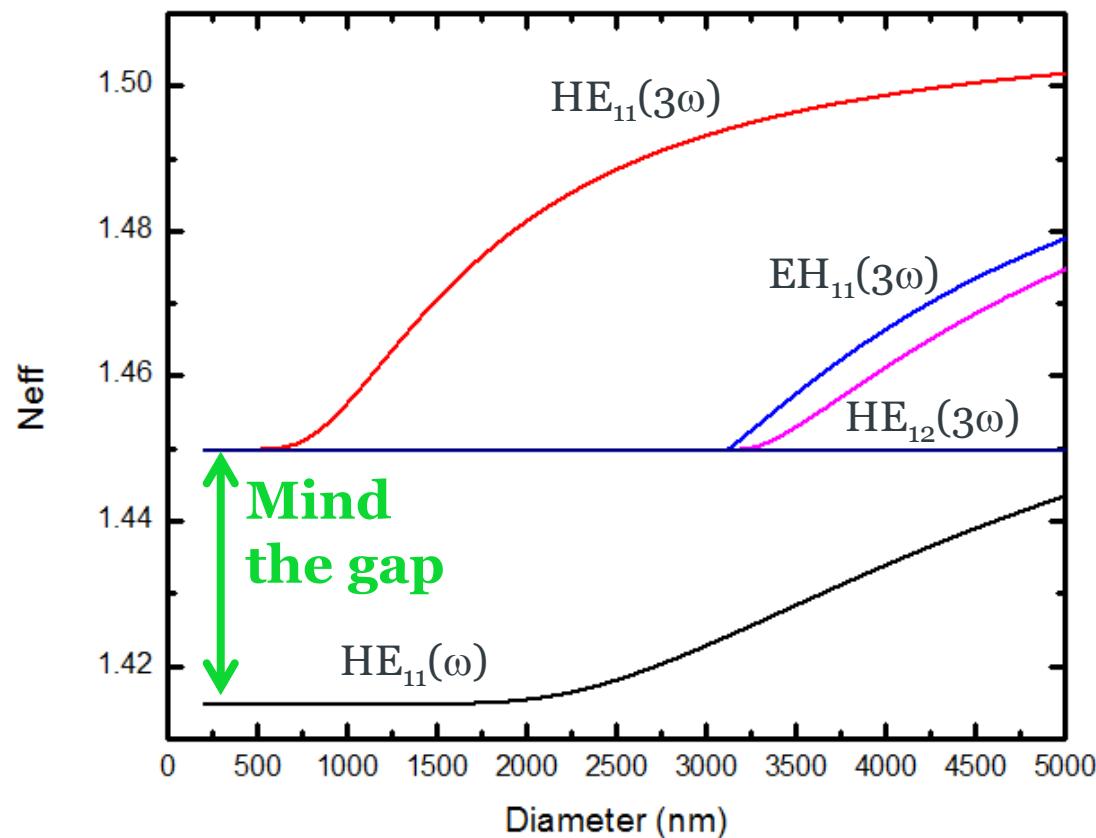


# Fibres: Phase matching

$\lambda_p = 1.06 \mu\text{m}$ ;  $\lambda_s = 3.18 \mu\text{m}$

Ge-doped silica fibre.  $[\text{Ge}] = 40\%$

NA  $\sim 0.42$



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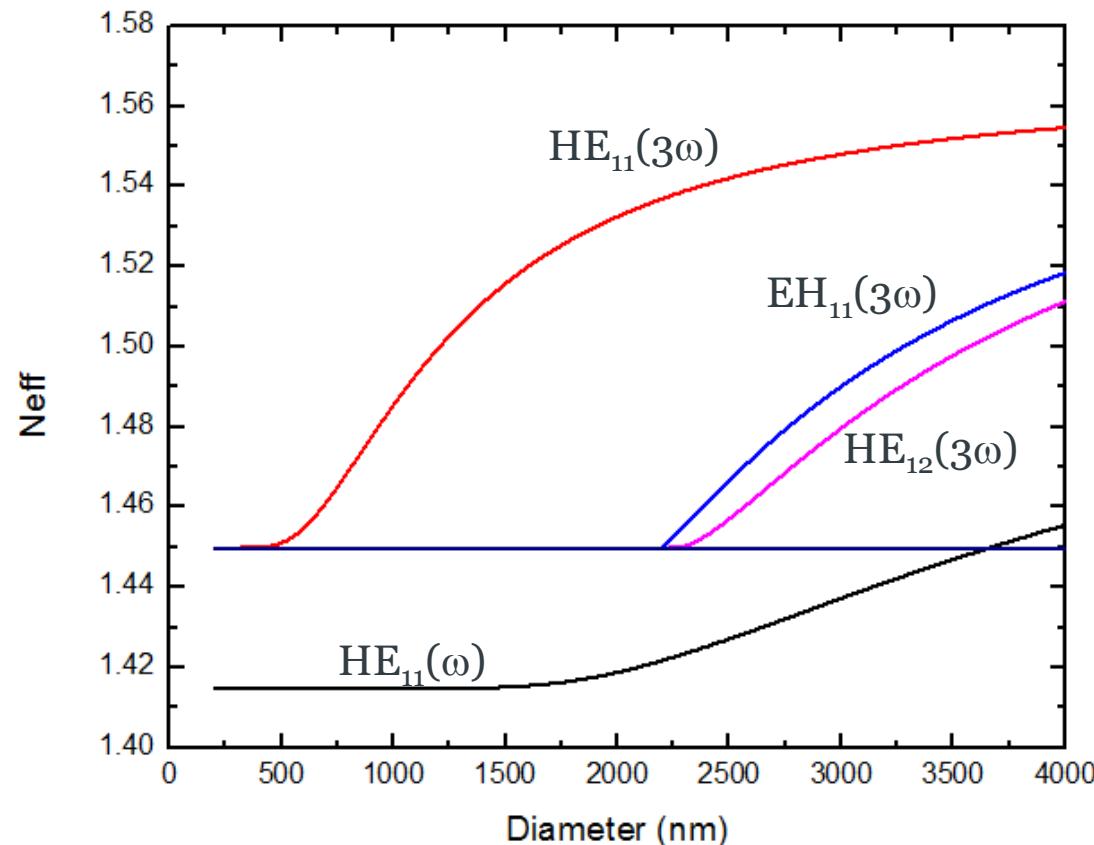
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# Fibres: Phase matching

$\lambda_p = 1.06 \mu\text{m}$ ;  $\lambda_s = 3.18 \mu\text{m}$

Ge-doped silica fibre.  $[\text{Ge}] = 60\%$

NA  $\sim 0.52$



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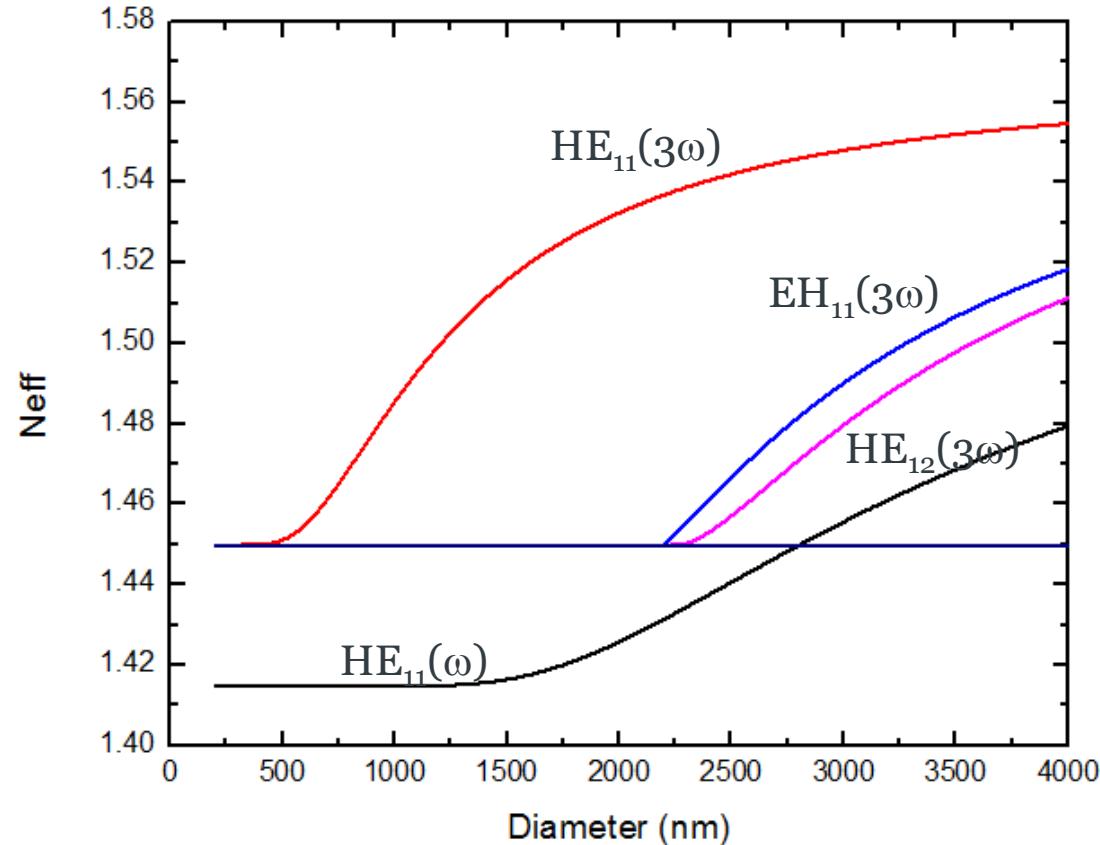
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# Fibres: Phase matching

$\lambda_p = 1.06 \mu\text{m}$ ;  $\lambda_s = 3.18 \mu\text{m}$

Ge-doped silica fibre.  $[\text{Ge}] = 80\%$

NA~0.6



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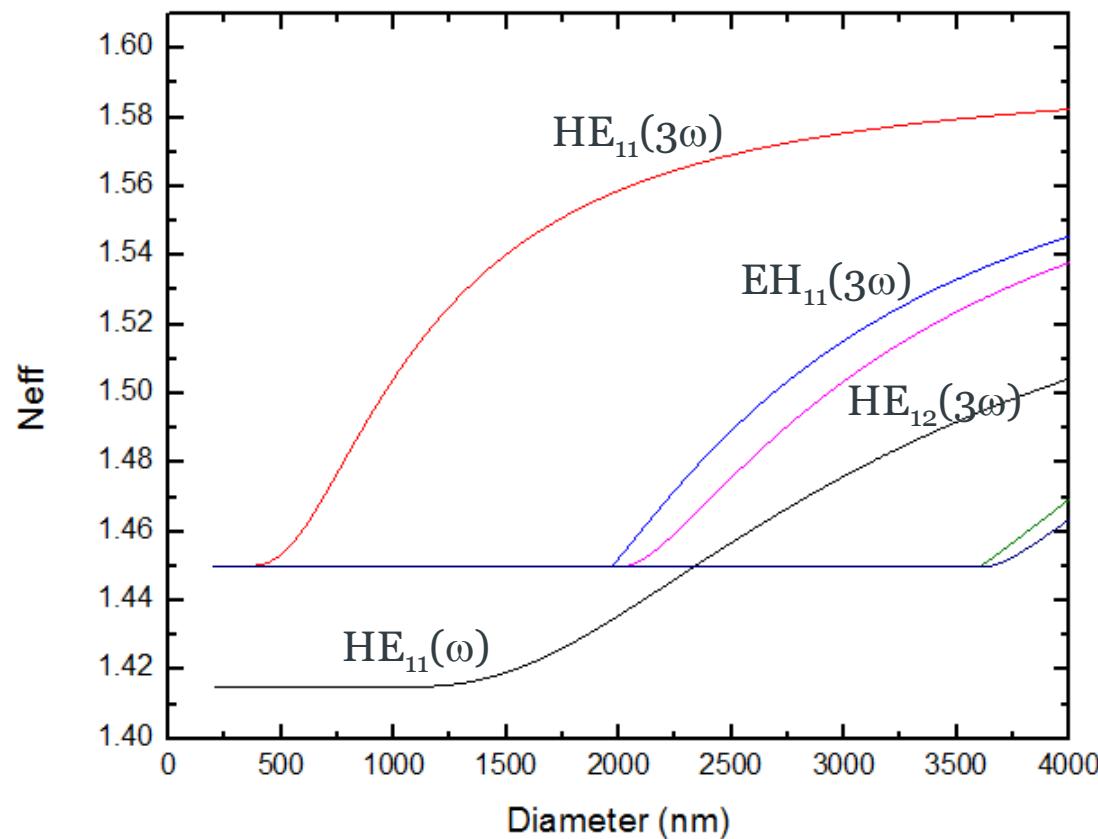
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# Fibres: Phase matching

$\lambda_p = 1.06 \mu\text{m}$ ;  $\lambda_s = 3.18 \mu\text{m}$

Ge-doped silica fibre.  $[\text{Ge}] = 100\%$

NA  $\sim 0.67$



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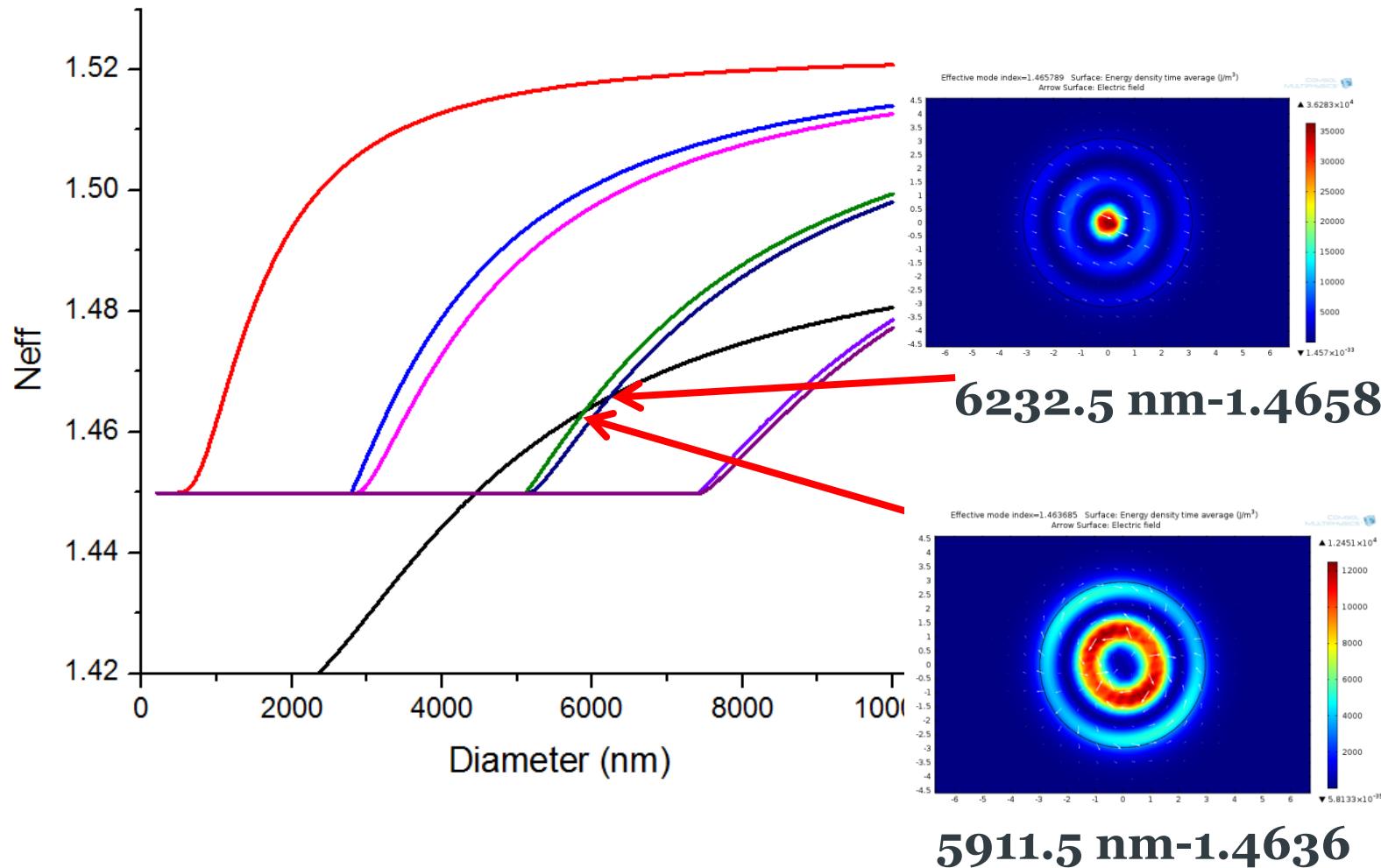
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# Fibres: Phase matching The Good News



PM takes place at large core diameters

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# Nonlinearity

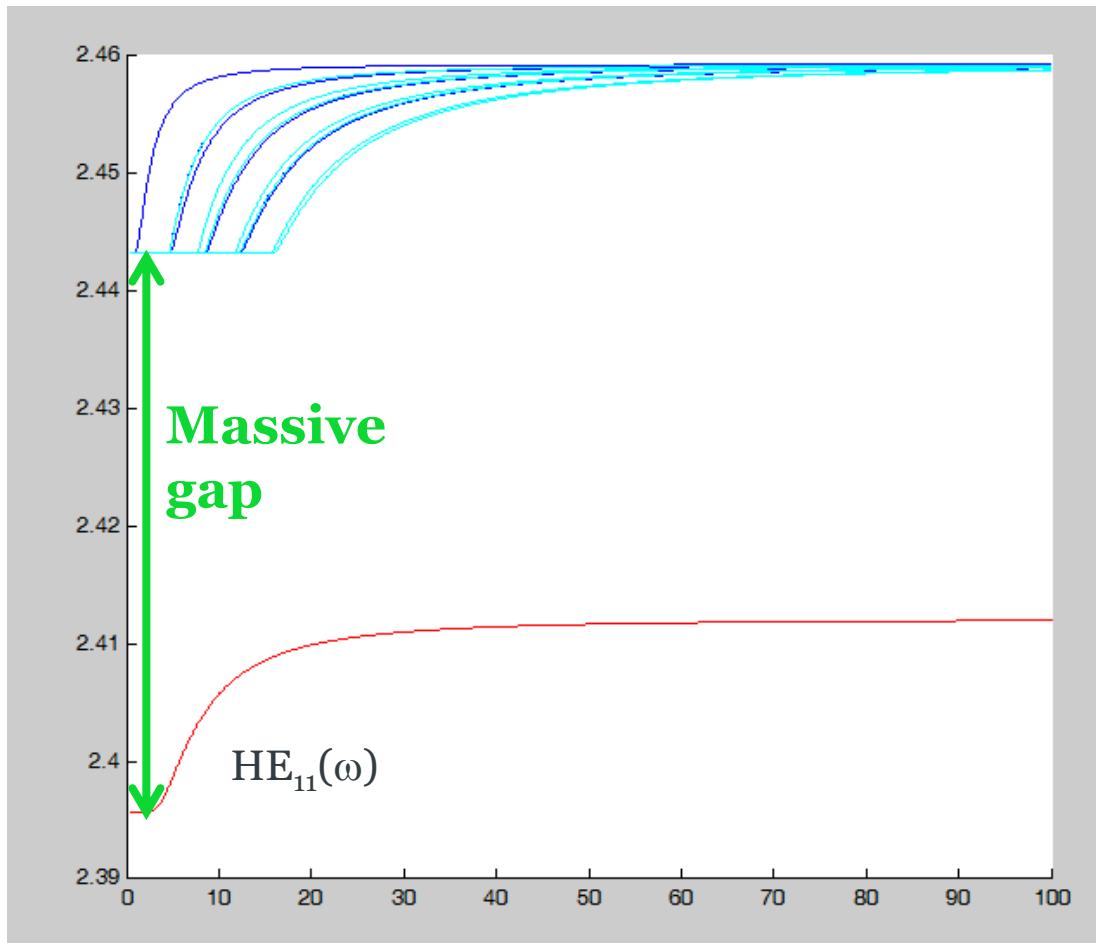
$$\gamma = \frac{2\pi}{\lambda} \frac{n_2}{A_{\text{eff}}}$$

Fiber Type	$\gamma$ @1550nm
Standard SMF	1
Pure silica microwire	>100
Lead Silicate microwire (F2)	~1000
Bismuth Silicate microwire	>6000
Chalcogenide microwire	up to 100000

# CHG fibres: Phase matching

$\lambda_p = 1.06\mu\text{m}$ ;  $\lambda_s = 3.18\mu\text{m}$

NA=0.28



In high n materials refractive index dispersion compensation is much more difficult

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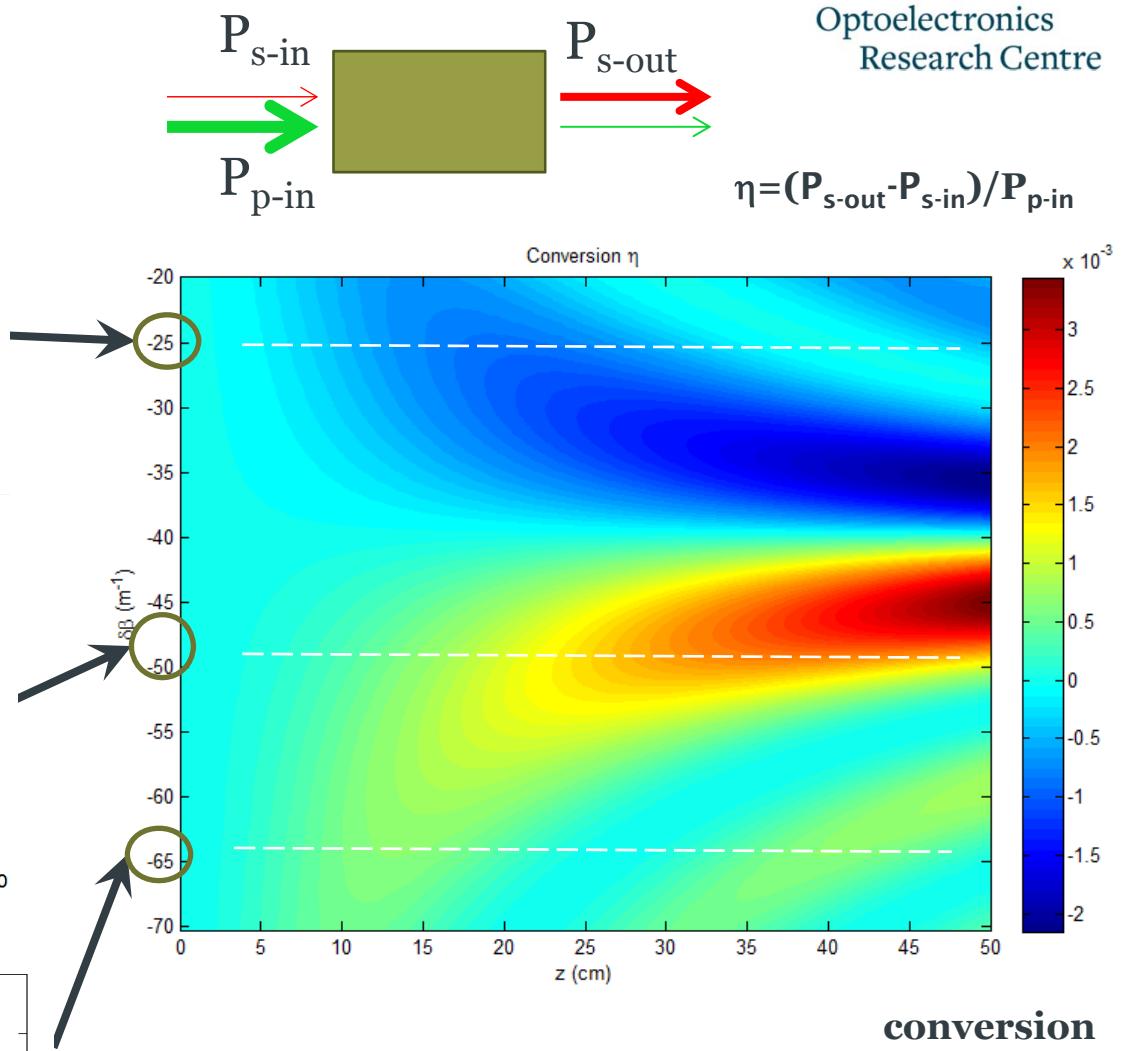
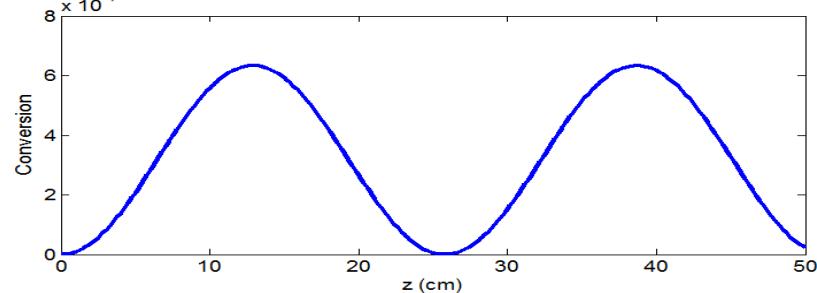
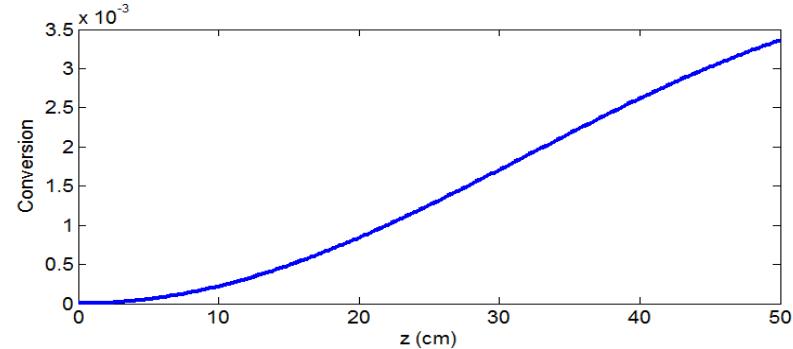
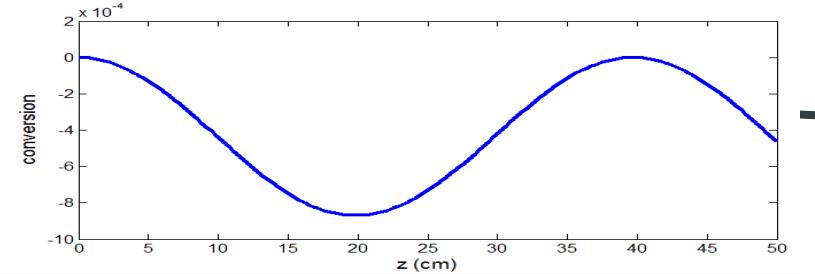
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# Fibres: detuning

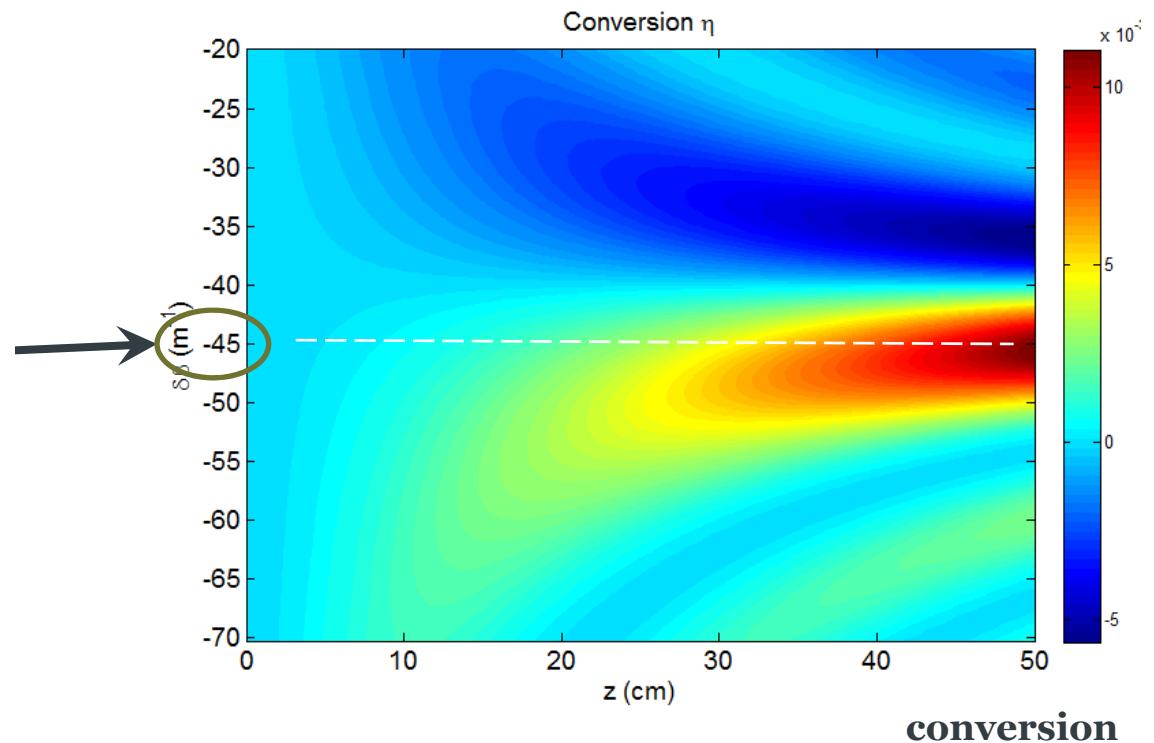
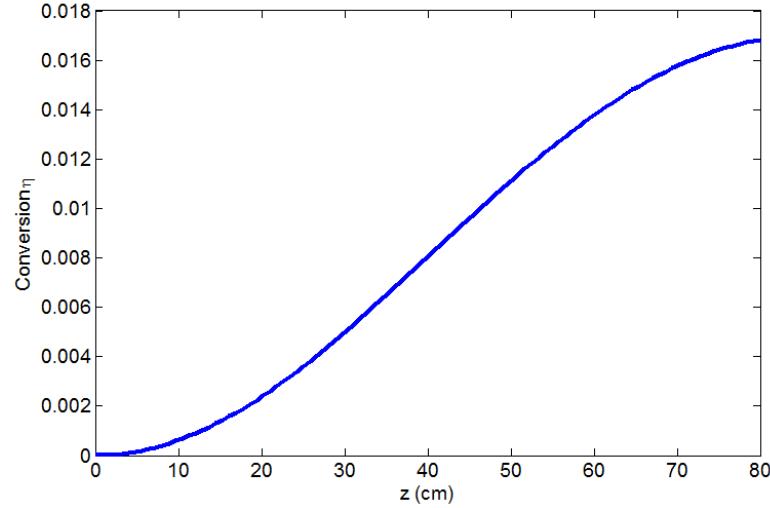
$P_s = 10\text{W}$ ,  $P_p = 1\text{kW}$



**conversion  
efficiency**

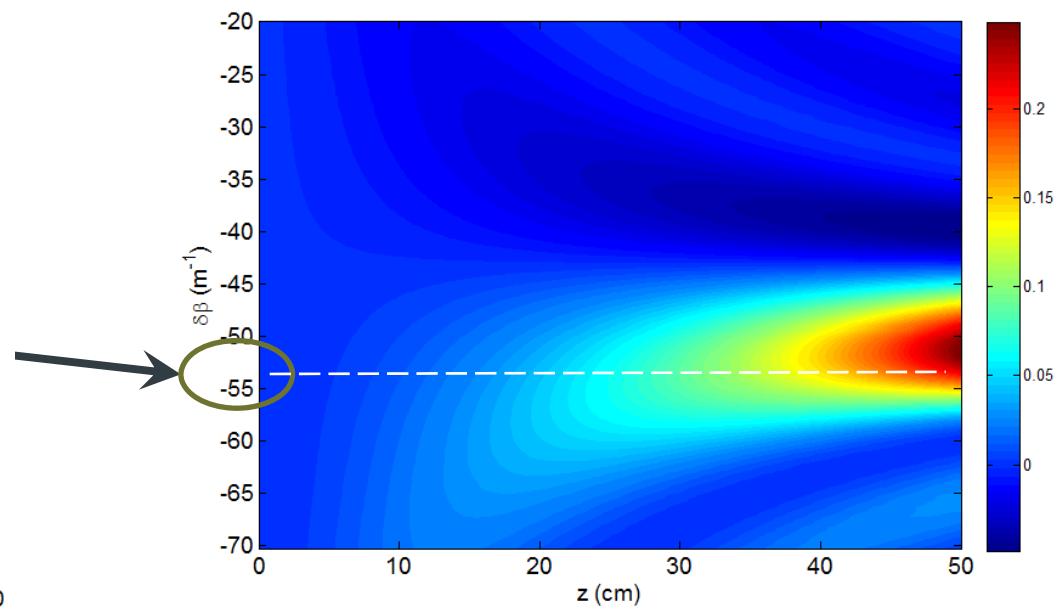
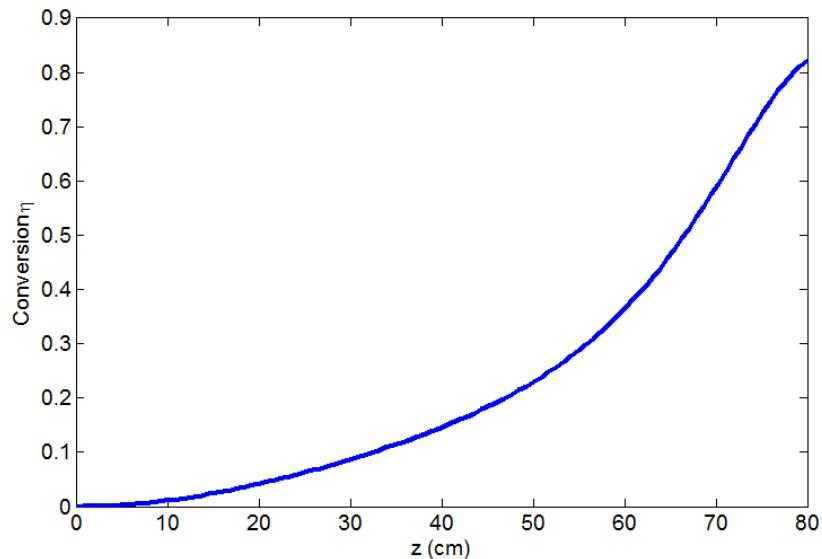
# Fibres: detuning

$P_s = 20\text{W}$ ,  $P_p = 1\text{kW}$



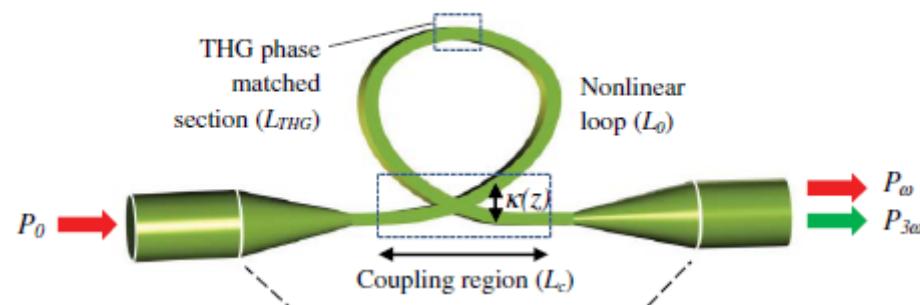
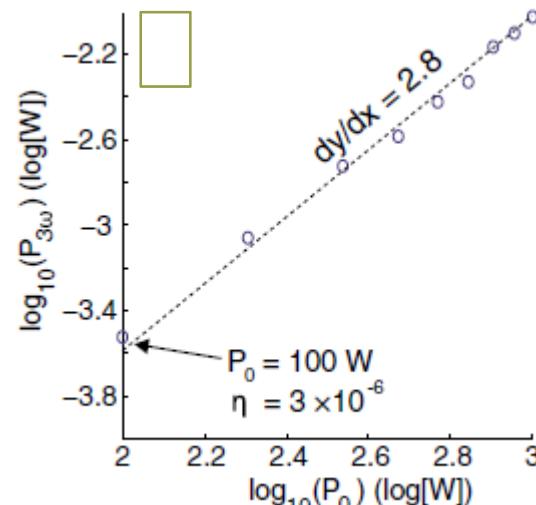
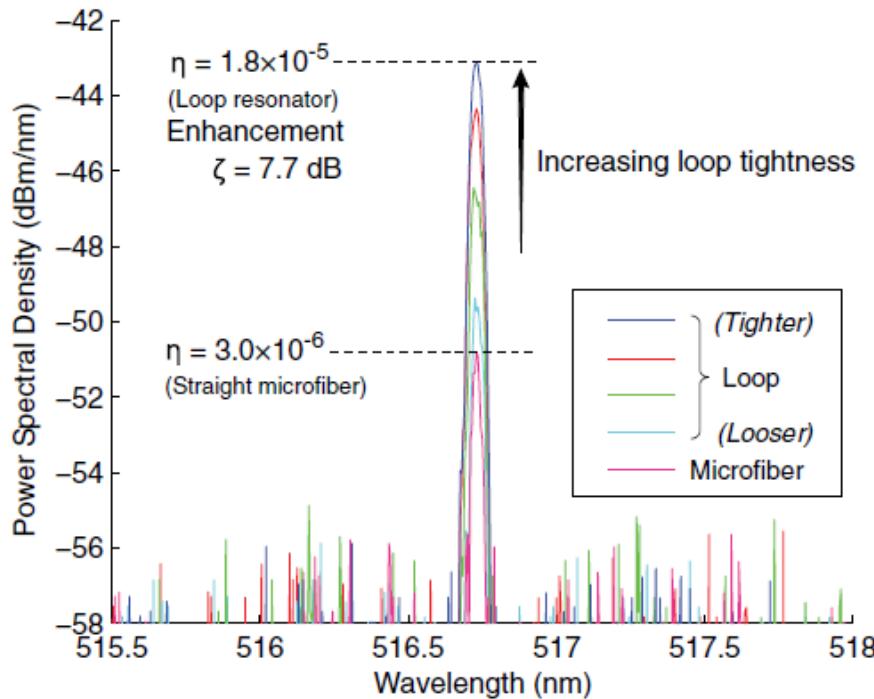
# Fibres: detuning

$P_s = 100\text{W}$ ,  $P_p = 1\text{kW}$



**conversion**

# THG: resonant effects



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# Conclusions

Silica has loss  $1\text{dB/mm}$  in the UV (200nm) and IR (up to  $4.5\mu\text{m}$ )

Fibres and tapers can be used to generate light in the UV or IR

Up-conversion (THG)  $\rightarrow$  UV generation

Down-Conversion (TPG)  $\rightarrow$  IR generation

Efficiencies as high as 90% have been predicted for phase-matched optimised diameters, detuning and length.

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# Acknowledgments

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Thank you  
questions?